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Gautier Tetard, Armelle Michau, Swaminathan Prasanna, Jonathan Mougenot, Pascal Brault, et al..
Discharge dynamics, plasma kinetics and gas flow effect in argon-acetylene discharges. Plasma Sources
Science and Technology, In press, 30, pp.105015. 10.1088/1361-6595/ac2a17. hal-03357911

HAL Id: hal-03357911

<https://hal.science/hal-03357911v1>

Submitted on 29 Sep 2021

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ACCEPTED MANUSCRIPT

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To cite this article before publication: Gautier Tetard *et al* 2021 *Plasma Sources Sci. Technol.* in press <https://doi.org/10.1088/1361-6595/ac2a17>

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Discharge dynamics, plasma kinetics and gas flow effect in argon-acetylene discharges

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Abstract

We investigated capacitively coupled Ar/C₂H₂ RF plasmas with a 1D fluid model that couples a 13.56 MHz discharge module, a long timescale chemical module and a flow transport module. A new solution procedure was developed in order to accurately describe the coupling between the short timescale discharge dynamics and the long characteristic time processes that play a major role in the molecular growth of reactive species. The plasma was simulated for different inlet gas configurations and flowrates. We showed that for a showerhead configuration one may distinguish two situations. For short residence time the plasma was strongly electronegative in the very center of the discharge gap and dominated by large hydrocarbon positive and negative ions. In this situation the acetylene conversion, although moderate, lead to a significant molecular growth. For long residence time, although C₂H₂ underwent a total conversion, the products of the primary C₂H₂ dissociation process were consumed by surface deposition which reduced drastically the molecular growth in the short gap discharge considered here. Whatever the conditions, we confirmed the key-role of Ar* in the acetylene conversion, ionization kinetics as well as the subsequent molecular growth for neutral and charged species. We also showed that remote feed gas and showerhead configurations predicted similar results at low flowrate. At larger flowrate the two configurations presented some discrepancy. Especially H₂ density was much larger for the remote feed gas configuration, which affected the overall plasma behavior. Our results highlight that realistic gas-flow models are essential for an accurate description of acetylene conversion in Ar/C₂H₂ plasma.

1. Introduction

Capacitively coupled RF (CCRF) discharges in hydrocarbon (HC) containing mixtures have been the subject of interest for many decades [1], [2], [3]. These discharges were indeed used fairly early for the deposition of a variety of (multi-)functional carbon, i.e., Diamond-Like-carbon(DLC) [4] or TaC [5], and hydrogen-carbon coatings (aC:H) [6] with applications in a large number of fields such as tribology [7], diffusion barriers [8], anti-corrosion coatings [9], adhesion-enhancement [6], nanocomposites elaboration [10], biomedical [11], just to cite few examples. Although the carbon deposits elaborated by HC-containing discharges enable reaching a large number of functionalities, the physical properties and functional characteristics of the deposits are usually highly sensitive to the process characteristics. Consequently, a fairly tight tuning of the deposition process is very often necessary in order to achieve targeted functional properties [12], [13]. This tuning requires investigating the effect of a significant number of process parameters, such as the nature of the HC

precursors, the feed gas composition, the pressure, the reactor configuration, the flow rate, the RF voltage magnitude, the gap distance etc. This makes a process optimization based on a simple parametric analysis hardly achievable in many situations, especially when taking into account the fairly rich (and sometime complex) physical phenomena and chemical processes that govern HC-containing discharge plasmas. This complexity motivated extensive experimental and modeling studies. Special attention was devoted to plasma-surface interaction, molecular growth, particle nucleation, dust particle dynamics and their impact on film deposition and/or nanostructures formation [14]. Beside coatings applications, the interest in these discharges was also motivated by the fundamental understanding of the production of analogs to extraterrestrial carbonaceous compounds and particles [15] on one hand and the issues of dust formation in tokamak fusion edge-plasma [16]. In particular, molecular growth and nanoparticle formation in acetylene and argon/acetylene RF discharges is receiving a constant attention, since more than two decades [1], [17], [18]. Concentrating on argon-acetylene CCRF plasmas, extensive experimental studies have been carried out to (i) investigate the space-time distributions of dust formation in the continuous or the pulsed regimes by laser light scattering and absorption [19],[20], (ii) thoroughly analyze the space-time evolution of both particle size and density by combination of Kinetic Mie ellipsometry and laser extinction [21], (iii) monitor hydrocarbon concentrations and analyze the chemical kinetics and the discharge dynamics by mass spectrometry and Tunable diode Laser Absorption spectroscopy [22],[23],[24],[25], (iv) investigate the initial clustering processes that induce particle nucleation by mass and molecular beam spectrometry [26] [27], (v) analyze the anion dynamics in the early stage of the discharge [28], (vi) study the particle cloud dynamics and its coupling with the discharge characteristics [29], [28], [30] and (vii) shed light on the role of argon metastables that turns out to be a key-species as far discharge dynamics and plasma kinetics are concerned [31], [32]. Besides these studies that were specifically dedicated to heterogeneous gas phase kinetics and plasma dynamics in Ar-C₂H₂ CCRF discharges, an experimental effort was also devoted to the investigation of the interaction of the plasma species and the growing deposit. These experiments provided the probabilities for sticking, recombination and, to a much lesser extent, more complex surface-reactions mechanism on a:C-H for some HC species [16], [33], which helps in describing the plasma-surface interaction and the coupling between surface processes, the discharge dynamics and the plasma composition. The large amount of key-information brought by these experiments enabled gaining insight in some of the processes that govern argon-acetylene CCRF discharges, giving guidelines for model development and validation. Actually, model developments were first carried out on pure acetylene CCRF plasmas with a first contribution from Doyle [34] and Stoykov et al. [35] who proposed a kinetic model taking into account the formation of large HCs, C_{n>2}H_y, in low pressure acetylene plasmas. These first models were used in the frame of quasi-homogeneous plasma assumption to investigate the clustering processes that leads to nanosized particle formation. They showed that although nucleation likely takes place through linear HC growth, the contribution of large Polycyclic Aromatic Hydrocarbon may be significant. Many steps forward have been achieved by Bogaerts and coworkers who integrated detailed chemical kinetic in one-dimensional plasma simulations where the discharge dynamics is properly taken into account [36]. This enables them analyzing under more realistic space-time distribution of the charged species and electron-temperature several molecular growth routes that may contribute to particle nucleation [37-40]. Beside these models that targeted the analysis of the combined molecular growth and discharge dynamics phenomena, other authors focused on the investigation of some aspects of the aerosol dynamics [37] such as coagulation, [10; 41]. This effort on acetylene plasma was followed few years

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3 later by the development of numerical models for argon-acetylene CCRF plasmas. The first models
4 were proposed by Schweigert and coworkers who investigated the impact of the growing
5 nanoparticles on the discharge characteristics [42], the change in an argon discharge behavior when
6 acetylene is added as impurity by the integration of a detailed chemical model inspired from those
7 developed for acetylene in one-dimensional discharge model [43]. Much more recently, Denysenko
8 and coworkers made use of a quasi-homogeneous model to investigate the chemical kinetics in RF
9 argon-acetylene plasmas [44; 45]. In particular these authors emphasized the role of argon
10 metastables on the discharge kinetics and analyzed the transient evolution of the plasma.

11 A close look to the literature reveals that argon-acetylene CCRF plasmas show many peculiarities
12 with a large number of questions that have still to be answered as far as modeling is concerned.

13 As a matter of fact, experimental studies addressing different discharge aspects, particle formation,
14 argon-metastables evolution, composition change, negative ion dynamic, etc. clearly showed that
15 argon-acetylene plasma may show very long time-evolution, i.e. up to several tens of seconds for
16 some effects. As a result, these plasmas are characterized by a very stiff dynamic with characteristic
17 times that range between sub-nanoseconds, for the electron energy dynamics, and several seconds
18 for large species or particles. This is for example the case of the addition of ethynyl radical ($C_2H\bullet$) on
19 polyyne [39]. Similarly the mutual neutralization between positive and negative ions shows
20 characteristic times of the order of 10^{-2} s. The complexity brought by this stiffness is further increased
21 by the necessity to resolve the RF period, i.e., 10^{-7} s, while describing the tight coupling that may exist
22 between phenomena or processes with very different characteristic times. To our best knowledge,
23 this issue has never been explicitly addressed in the literature. In particular, the way the very fast
24 discharge dynamics is coupled to the much slower molecular growth kinetics or large negative ions
25 transport has never been thoroughly discussed. This point is especially critical when considering the
26 strong coupling between the fairly slow molecular growth and attachment kinetics that end up with
27 the formation of large negative ions and the very fast discharge dynamic that is affected by these
28 ions. Therefore, in this paper, we discuss a new solution procedure that enables taking into account
29 such coupling. Beside the classical balance equations used in fluid models, this procedure makes use
30 of a set of non-stationary short time-scale averaged equations where almost all the species can be
31 followed over long time scales.

32 Further, the long time-evolution, from several to tens of seconds, of acetylene and/or
33 argon/acetylene plasmas raises the question on the effect of the feed gas flow velocity and
34 configuration on the plasma behavior. In particular, one may expect that some collisional effects or
35 transport phenomena may show characteristic times that are of the same order of magnitude as the
36 residence time. In such a case the discharge behavior cannot be affected by the only flowrate value
37 but also by the flow configuration. As a matter of fact, CCRF argon-acetylene plasmas were
38 generated under both showerhead electrode and remote feed gas configurations with flowrate
39 ranging between 1 and 20 sccm and residence estimated between 500 ms and 50 s depending on the
40 discharge gap and the reactor volume [46], [47], [48]. Obviously, such differences in the residence
41 time and the flow configuration may result in different plasma compositions and discharge
42 characteristics even for the same working pressure feed gas composition and RF voltage. We believe
43 therefore that the flow effect on the plasmas composition and discharge behavior should be
44 thoroughly investigated. In particular, many experiments showed a very large conversion of
45 acetylene, i.e., more than 90%, in argon-acetylene plasmas [32], [24],[25]. Such a high conversion
46 yield raises the question on the fate of acetylene and the nature of hydrocarbon species that actually
47 interact with electrons. Although previous modeling works showed a significant conversion of

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3 acetylene and gave indication on the resulting species, we believe that this question needs further
4 analysis. In particular, we will show that the conversion yield of acetylene and the discharge behavior
5 strongly change with the flowrate and the feed gas inlet configuration. Lastly, from more
6 fundamental point of view, the extensive work of Stefanovic and coworkers on argon-acetylene CCRF
7 plasmas emphasizes the key role of argon metastables in argon-acetylene discharges [31],[32]. This
8 effect has been taken into account in one-dimensional model in [43] and was also very recently
9 underlined and thoroughly analyzed through modeling by Denysenko et al. [45] who used a volume
10 averaged plasma model. We propose in this article to analyze argon metastable effect while taking
11 into account more accurate discharge dynamics. We propose in particular to investigate how this
12 species is involved in the interplay between discharge dynamic, plasma kinetics, gas flow convective
13 transport.

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17 In this article, we mainly focus on the investigation of flow effect during the molecular growth stage
18 prior to any solid particle formation which is therefore not considered in the present model.
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21 We make use of a one-dimensional self-consistent numerical fluid model of argon-acetylene plasmas
22 along with a new solution procedure where a set of short-time-scale averaged transport equations
23 are considered in order to track the long-time-scale evolution of the plasma. The model self-
24 consistently solves for the discharge dynamic equations (fluid model), flow momentum equations for
25 showerhead inlet stagnation flow configuration and short-time-scale averaged transport equations
26 for chemical species. We also propose and discuss a set of non-linear mass-conserving boundary
27 conditions that are consistent with stagnation flow configuration and enable properly taking into
28 account mass transfer during HC deposition. A special effort was indeed devoted to insure the mass
29 conservation without introducing any normalization or correction procedure so as to insure an
30 accurate Ar/C/H balance in these highly reactive discharges. The developed model was used to
31 investigate how the flow velocity and configuration affect the plasma behavior in terms of
32 composition, key-species and governing processes. We particularly show that the neutral plasma
33 composition dramatically change with the flow velocity and may strongly differ from the feed gas
34 composition. We underline how the ionization kinetics, the discharge electronegativity and the
35 acetylene conversion yield change with the flow velocity. We compare three different flow
36 configurations: a first one where the feed gas composition is assumed at the showerhead electrode,
37 a second one where the back-diffusion and surface reaction at the showerhead electrode are taken
38 into account and a third one where a remote feed gas configuration is assumed.

39
40 In the next section the fluid model used is presented with special emphasis on (i) the short-time-scale
41 averaged transport equations used to track chemical species over long time-scales, (ii) the flow
42 models used to describe the showerhead and the remote feed gas inlet configurations and (iii) the
43 boundary conditions used. The discharge drift-diffusion and chemistry models used are essentially
44 taken from the literature and are therefore described more briefly with a special emphasis on the
45 change/improvement that we made in this work. In section 3 we present the main results obtained
46 on the effect of the gas flow on the discharge behavior. We first analyze in detail the plasmas
47 obtained when using a convective flow boundary conditions at the showerhead electrode, i.e. when
48 the composition at the showerhead electrode is assumed to be the same as the feed gas
49 composition. Then, we discuss the case where more realistic boundary conditions taking into account
50 the back-diffusion and surface reaction at the showerhead electrode are taken into account. In this
51 section we will also show how the flow velocity affects the plasma behavior. Then, we compare the
52 plasmas compositions obtained for showerhead and remote flow inlet configurations. A brief
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summary of the results and the major conclusions and perspectives that may be drawn from this work are given in the last section.

II. Model description

II. 1. Modeling principle

The acetylene plasmas generated in the capacitive coupled RF discharges show very large stiffness since the characteristic time of the discharge dynamic is below 10^{-7} s while the chemistry may take place over tens of seconds when molecular growth and particle formation occur [19]. In order to treat such stiffness, one may separate the species in two groups according to their characteristic times. The first group considers the species with chemistry/transport characteristic times that are below or of the order of the RF period. The second group gathers those species with characteristic times much greater than the RF period. This time-scale separation would naturally results in a plasma model involving a first sub-module that describes the discharge physics taking place over the RF period time-scale and a second sub-module called Large characteristic time transport/chemistry module (LCT Module) that describes the coupled phenomena of chemistry and transport taking place over much longer time-scales.

One of the major issues encountered when using this separation is related to the coupling between the two time-scales and more specifically to the feedback of large time-scale evolution of the plasma composition on the short time-scale discharge dynamics. This issue is particularly difficult to address in the case of long time-scale variations of the charged species, especially negative ions. Therefore, these ions are treated independently in the two sub-models where the discharge module tracks the small time-scale dynamics of these ion species within a RF period and the LCT module considers a time averaged representation of these ions to predict their evolution over longer time-scales. The coupling between the two sub-modules is enforced by the iterative exchange of these species until convergence.

These two sub-models have to be complemented by a fluid-flow model that gives the flow velocity and/or the gas flow related convection fluxes in the gap. These fluxes may indeed bring a substantial contribution in the species and energy balance equations, especially for large characteristic time species. The three sub-modules and the dedicated solution procedure used in the present work are presented in the following.

We are especially interested in describing how the gas flow may affect the plasma composition and subsequently the discharge dynamic and the detailed chemistry that leads to nucleation. Although the dust particle formation is not taken into account, the chemical model involves a large number of species and reactions and shows strong stiffness. Therefore, in order to keep the numerical solution tractable, we consider a one-dimensional model where the plasma composition is investigated on the central axis along the gap between the powered and the grounded electrodes. Such a one-dimensional model is especially suitable when the gap distance is small as compared to the electrode diameter.

II. 2. Discharge dynamic model

The discharge module solves for the charged species densities, the electron energy and the electric field over a time scale shorter than the 13.56 MHz RF period. For this purpose we used a classical fluid model assuming a drift/diffusion transport [49] that involves a mass conservation equation, expressed in terms of mass fraction Y_s , for each plasma species :

$$\rho \frac{dY_s}{dt} = -\frac{d\Gamma_s}{dx} + S_s + F_s \quad (1)$$

Where ρ is the gas density, while Y_s , Γ_s and S_s represent the mass fraction, the drift/diffusion flux and the net mass production rate by collisional processes for species 's'. The term F_s represents the contribution of the gas flow convection flux in the balance of species 's'. It may involve either a flux divergence term or a source term depending on the flow configuration and model used. This term will be discussed in section II.3.

The low inertia electrons follow the RF field dynamic. The drift-diffusion flux is given by the local time-varying electric field E . We therefore have:

$$\Gamma_e = -D_e \rho \frac{Y_e}{x_e} \frac{dx_e}{dx} - \mu_e E \rho Y_e \quad (2)$$

Where D_e and μ_e are the diffusion and mobility coefficients for electrons.

The ionic species have much larger inertia and their oscillations under the action of the RF field may be strongly damped. In principle, a momentum equation has to be considered for each ion in order to determine the pressure/electrostatic forces generated ion transport velocity and flux. This would however increase the size of the governing equations set, which would introduce major difficulties in their numerical solution. We therefore used the simplified procedure proposed in [49], where a drift-diffusion transport model using an effective electric field E_s derived from the damping equations is adopted for each ion 's' :

$$\frac{dE_s}{dt} = -\nu_{QM-s}(E_s - E) \quad (3)$$

Where ν_{QM-s} the momentum exchange collision frequency for the ion 's'. The ion flux is then expressed using drift-diffusion equation similar to (2) where the effective electric field is used instead of the electric field.

The time varying local electric field is determined taking into account the plasma space charge using Poisson's equation.

The expressions of the net mass production rates by collisional processes for the different species depend on the chemical model and rate constant data used. The reaction rate constants and the transport coefficients involved in the species balance equations highly depend on the gas temperature and the electron energy distribution function (eedf). In the present model the gas temperature T_g is assumed to be constant and is treated as a model input parameter. On the other hand, the eedf may be well approximated by the solution of the two-term expansion of the Boltzmann equation since the investigated plasmas are fairly collisional. We then make use of an off-line Boltzmann solver to determine the eedf, the resulting electron temperature, $T_e = \frac{2 \langle \epsilon_e \rangle}{3 k_b}$, and transport coefficients over a wide range of reduced electric field value. The electron-impact reaction rate constants and electron transport coefficients were curve-fitted as function of the electron temperature. These curve-fits were used in the plasma model in order to self-consistently determine

the rate constants and the transport coefficients as function of the electron temperature that is determined by solving the following electron energy balance equation:

$$\frac{d}{dt}(n_e \varepsilon_e) = -\frac{d\Gamma_{\varepsilon e}}{dx} + S_{\varepsilon e} - eE\Gamma_{\varepsilon e} \quad (4)$$

Where $\varepsilon_e = \frac{3}{2}kT_e$, n_e , $\Gamma_{\varepsilon e}$ and $S_{\varepsilon e}$ denote the average energy, density, enthalpy flux and energy loss rate through collisional processes for electrons.

The electron enthalpy flux is given by:

$$\Gamma_{\varepsilon e} = \frac{5}{3}\mu_e(T_e)n_e\varepsilon_eE - \frac{5}{3}D_e(T_e)\frac{dn_e\varepsilon_e}{dx} \quad (5)$$

II. 3. Large characteristic time transport/chemistry module (LCT Module)

As mentioned previously, many of the neutral species involved in the hydrocarbon plasma chemistry show characteristic times (in the order of 1 s) much longer than the RF period ($\sim 10^{-7}$ s). These species may affect the discharge dynamic over a very long time scale. Describing this effect by integrating the transport equations of these species within the discharge module is computationally expensive. Therefore, we have developed a second module that is specific to long characteristic time species and where the considered equations are derived from the time-average of the species continuity equations over one RF period. These may be expressed as follows:

$$\left\langle \rho \frac{dY_s}{dt} \right\rangle_{T_{RF}} = -\frac{d\langle \vec{\Gamma}_s \rangle_{T_{RF}}}{dx} + \langle S_s \rangle_{T_{RF}} + \langle F_s \rangle_{T_{RF}} \quad (6)$$

Where $\langle f \rangle_{T_{RF}}(t) = \frac{1}{T_{RF}} \int_{t-\frac{T_{RF}}{2}}^{t+\frac{T_{RF}}{2}} f(t) dt$ is the time-average of f over one RF period. Here we are interested in the time-variation of $\langle f \rangle_{T_{RF}}$ over time-scales much longer than the RF period.

Actually, most of the neutral species (the only exception is Ar*) show transport and chemistry characteristic-times that are much longer than the RF period so as $\langle Y_s \rangle_{T_{RF}}(t) \approx Y_s$. Similarly the change in the gas density remains moderate and takes place on time scales that are much longer than the RF period so as $\langle \rho \rangle_{T_{RF}}(t) \approx \rho$. Also, the transport fluxes for these species only include constant or slowly varying quantities. This means that for the neutral species:

$$\langle \Gamma_s \rangle_{T_{RF}} = \left\langle -D_s \rho \frac{Y_s}{x_s} \frac{dx_s}{dx} \right\rangle_{T_{RF}} \approx -D_s \rho \frac{Y_s}{x_s} \frac{dx_s}{dx} \quad (7)$$

and

$$\langle F_s \rangle_{T_{RF}} \approx F_s \quad (8)$$

As for the source term S_s , one may distinguish two components. A first one, S_{s-e} , that involves electron-impact processes, and a second one, S_{s-hs} , that involves only heavy species. The rates of reactions between heavy species depend on their densities that are generally slowly varying and on the constant gas temperature that determines the rate constants. This means that we have $\langle S_{s-hs} \rangle = S_{s-hs}$. The electron-impact component of the source term may be written as:

$$S_{s-e} = \sum_r \alpha_r k_r(T_e) n_e n_p \quad (9)$$

Where 'p' is the species that react with the electron in reaction 'r', $k_r(T_e)$ is the rate constant of process 'r', α_r is a constant coefficient that depends on the contribution of species 's' in reaction 'r'. For most cases, the only factors that vary very rapidly in the expression of S_{s-e} are the rate constant that depends on T_e and the electron density. The expression of the time-averaged value of S_{s-e} over one RF period may be written:

$$\langle S_{s-e} \rangle_{TRF} = \sum_r \alpha_r \langle k_r(T_e) n_e \rangle_{TRF} n_p \quad (10)$$

Taking into account the discussion above, the expression of time-averaged continuity equations of long characteristic-time (LCT) species may be written as:

$$\rho \frac{dY_s}{dt} = -\frac{d\Gamma_s}{dx} + S_{s-hs} + \langle S_{s-e} \rangle_{TRF} + F_s \quad (11)$$

The electron-impact component of the source term is evaluated in the discharge dynamic module discussed in the previous section.

Actually, the procedure discussed above for neutral species may be also used in the case of ionic species that show very small time-space variation during a single RF cycle. This is especially the case for the low mobility large ions that are produced during the molecular growth. It is also the case for the negative ions, the evolution of which is at least partly governed by the fairly long ion-ion mutual neutralization process. For this purpose we solved long time evolution of these species by introducing image-ion in this sub-module. The time-averaging procedure of the continuity equations for these image-ions is similar to that for neutrals except that the drift terms needs to be averaged also. If constant diffusion and mobility coefficients are assumed for the ions, the averaged drift-diffusion flux may be expressed as:

$$\langle \Gamma_s \rangle_{RF} = -D_s \rho \frac{Y_s}{x_s} \frac{dx_s}{dx} - \mu_e \langle E_s \rangle_{RF} \rho Y_e \quad (12)$$

The time-averaged effective electric field $\langle E_s \rangle_{RF}$ is equal to the time-averaged electric field and corresponds therefore to the DC component of the field, i.e., $\langle E_s \rangle_{RF} = \langle E \rangle_{RF} = -\frac{dV_{DC}}{dx}$.

The $\langle E_s \rangle_{RF}$ required in the LCT Module is therefore obtained from the discharge module.

II. 4. Gas-flow models

The flow field in CCRF plasma reactors is generally fairly complex and its detailed description would require 3D flow modeling. However, if one is only interested in the flow field inside the gap region, two model-configurations that correspond to either showerhead feed gas inlet or remote can be treated in the frame of a 1D model. In the first configuration, the flow enters the simulation domain axially through one of the electrode. The flow shows a stagnation line configuration that requires solving for the axial velocity profile in the discharge gap. In the second situation where a remote feed gas inlet is used, the feed gas is introduced across the lateral surface of the gap over the entire inter-electrode domain.

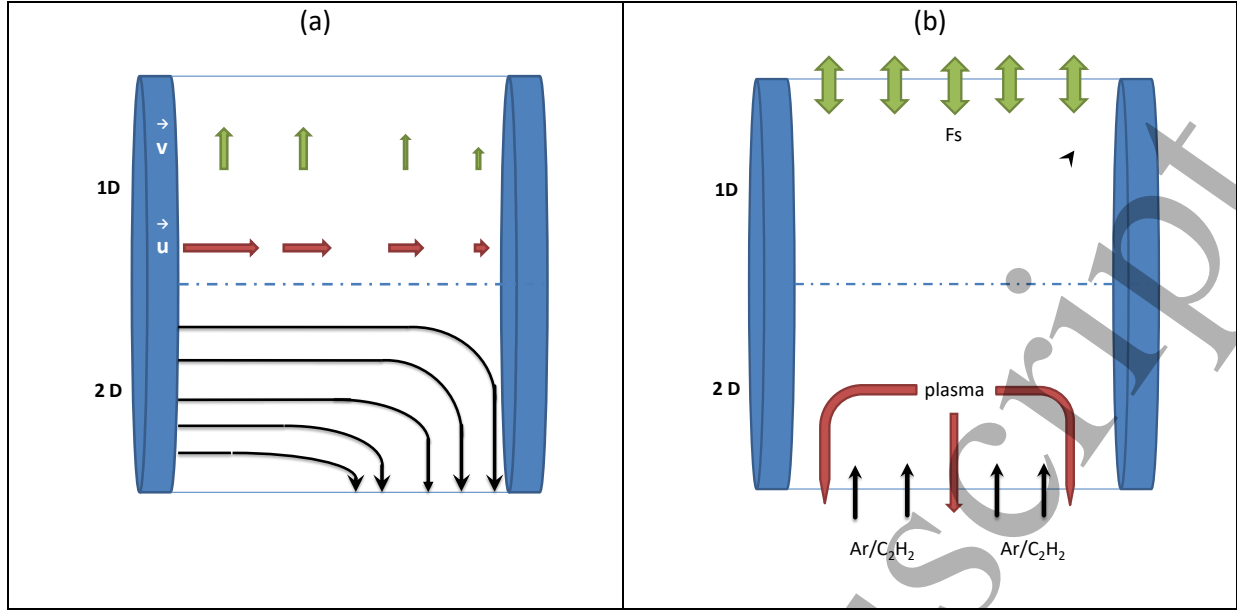


Figure 1 : feed gas configuration (a) showerhead and (b) remote. The lower part represents the 2D representation of the flow and the upper part the 1D equivalent. \bar{u} and \bar{v} are the axial and radial velocity components of the flow for the showerhead feed gas configuration and F_s is the flow contribution to the mass balance equation (equation 15 for the showerhead feed gas configuration and equation 16 for the remote gas inlet configuration).

- Showerhead gas inlet configuration

The first situation corresponds to a showerhead inlet and a stagnation flow configuration. In this case we approximate the showerhead electrode (left electrode in figure 1) by a porous body from which a purely axial flow emerges and is directed toward the facing electrode (the Stagnation Electrode) which then locally stops the flow. In this stagnation point configuration, the flow exits radially outside the inter-electrode domain. Coltrin et al [50] proposed a simple mathematical model for the description of such stagnation flow configuration. This model assumes a parabolic stream function and a constant radial component of the pressure gradient. The resulting variation of the axial velocity along the stagnation line, i.e., the gap, is described by two physical quantities, the axial velocity u , and the so-called acceleration factor at the stagnation line: $V = \frac{v}{r}$ where v is the radial velocity. The flow velocity and acceleration factor in the gap are governed by the following set of continuity and radial momentum conservation equations [51]:

$$\frac{d\rho u}{dx} + 2\rho V = 0 \quad (13)$$

$$\rho u \frac{\partial V}{\partial x} + \rho V^2 = -\Lambda + \frac{d}{dx} \left(\eta \frac{dV}{dx} \right) \quad (14)$$

Where η is the dynamic viscosity and $\Lambda = \frac{1}{r} \frac{\partial P}{\partial r}$ is a constant that characterizes the stagnation flow. In the considered finite-gap situation, Λ is determined iteratively to satisfy the imposed velocity values u_{elec} at the boundary. The contribution of the flow rate, F_s , to the species mass balance equations (1) and (11) includes two components: a convective flux divergence term that describes the convective transport along the gap and a source term corresponding to the radial convective losses along the stagnation line. This contribution may be written:

$$F_s = -\frac{d\rho Y_s}{dx} + Y_s \frac{d\rho u}{dx} \quad (15)$$

- *Remote feed gas inlet configuration*

The way the effect of convective flow is treated in the literature corresponds approximately to this configuration [43]. Actually, in this configuration, the flow effect will strongly depend on the ratio of the discharge to the reactor volumes, $\delta = \frac{V_D}{V_R}$, that determines the residence time in the discharge gap. A literature survey shows that this parameter is generally not precisely indicated. Estimates from the data given on experimental CCRF plasma reactors in some references would indicate that this parameter may vary by almost one order of magnitude from one case to another [44],[47]. Therefore, in this work we considered two asymptotic cases. The first one corresponds to $\delta \rightarrow 0$, which means that the discharge volume is very small with respect to the reactor volume. In this case the composition outside the discharge volume would not be affected by the discharge and would be similar to the feed gas composition. The situation corresponds therefore to an infinite dilution of the discharge products in the surrounding reactor volume. The gas flow effect may be described through a simple uniform mass transfer along the lateral surface of the discharge. The flow contribution to the species balance equations may be expressed:

$$F_s = h_s(\rho_s - \rho_s^{feed}) \frac{4}{D_{electrode}} \quad (16)$$

Where h_s is a mass transfer coefficient, $h_s = \frac{D_s}{D_{electrode}}$, $D_{electrode}$ is the electrode diameter, and ρ_s^{feed} is the species density in the feed gas.

The second situation corresponds to $\delta \rightarrow 1$, which means that the discharge occupies the entire reactor. In this case, the inlet mass flow of species 's' corresponds to the mass flow of 's' in the feed gas. The outlet mass flow for species 's' is given by the product of its mass fraction in the discharge by the total mass flow exiting the reactor. The flow contribution to the species balance equations is written:

$$F_s = \frac{(Q_m^{inlet} Y_s^{feed} - Q_m^{out} Y_s)}{V_{plasma}} \quad (17)$$

Y_s^{feed} denotes the mass fraction of the different species in the feed gas. V_{plasma} is the discharge volume. Q_m^{inlet} and Q_m^{out} are the inlet and outlet mass flowrates. They may differ since deposition on the electrodes may take place.

II. 5. Chemistry model, collisional and transport data

We have used a chemistry model that is essentially similar to the ones discussed in references [39] and [44]. We will give only a brief description of the main processes considered. The electron impact reaction-set involves (i) ionization of Ar, Ar*[52], C₂H₂ and H₂, (ii) dissociation of C₂H₂ and H₂ and (iii) dissociative attachment processes of C₂H₂. Acetylene ionization and dissociation also takes place through quenching by Ar* which, due to its key-role [32], is considered as a chemical species in the model. The rate constant used from these processes are taken from [53] and correspond to

ionization/dissociation branching ratio of 0.7/0.3. More recently, Stefanovic et al suggested the inverse value, i.e., 0.3/0.7, that was determined from the comparison between measured and calculated time decays of the electron density during the afterglow of an RF discharge [32]. Therefore the sensitivity of our results to this parameter was investigated. The first series of primary reactions discussed above results in the formation of (i) small ions, i.e., Ar^+ , C_2H_2^+ , C_2H^+ , C_2H^- , (ii) radicals, i.e., C_2H , C_2 , CH , and (iii) a significant amount of molecular and atomic hydrogen. Both negative and positive primary hydrocarbon ions produced by this set of reactions undergo a series of ion-conversion reactions by collisions with C_2H_2 and C_2H , which results in molecular growth and formation of large positive, C_nH_v^+ , and negative, C_nH^- ions with even number of carbon [48]. In the present model we describe this molecular growth up to 8 carbons. The considered neutral kinetics is very similar to the one described in reference [39]. It particularly includes neutral molecular growth route through addition of C_2H_2 and C_2H which results in the formation of large C_nH_2 polyene molecules and the corresponding C_nH radicals. The large negative-ions and neutral molecules are coupled through dissociative attachment of polyynes [54] [55] and radiative attachment on C_nH radicals [56]. They are also coupled through positive-negative ion mutual neutralization processes which represent the only loss process for the negative ions. The positive ion and neutral species kinetics are coupled through Penning ionization of acetylene by Ar^* [32], dissociative recombination of positive ions, positive-negative ion mutual neutralization processes and surface recombination.

Beside these reactive processes we have also considered a set of collisional processes that are involved in the electron energy dissipation and do not affect the plasma composition. In particular, we took into account (i) the excitations of the first three vibrational levels and the first two non-dissociative electronically excited states of H_2 that are responsible for the major part of electron energy dissipation through $e\text{-H}_2$ collisions, (ii) the excitation of the three vibrational levels and the electronically excited states of C_2H_2 [43] and (iii) the excitation of argon radiative states [52].

The mobility coefficients for ions were determined using Langevin theory and Blanc's mixing law [57] assuming that the background gas is essentially composed of argon, C_2H_2 and hydrogen. The ion diffusion coefficients D_j (in $\text{m}^2\cdot\text{s}^{-1}$) of the ionic species are inferred from the mobility coefficient using Einstein equation [58]. The diffusion coefficients of the neutral species were estimated using Lennard-Jones parameters and a Blanc's mixing law where the background gas is assumed to be dominated by argon, acetylene and hydrogen.

II. 6. Boundary conditions

In order to solve the species continuity, the electron energy and Poisson's equations, boundary conditions are to be specified at the electrodes.

As for Poisson's equation the voltage values at the powered and the grounded electrodes are given, i.e., $V(x = 0) = V_0 \cdot \sin(\omega t)$ and $V(x = L) = 0$

The species boundary conditions at the electrodes used in this work takes into account the possibility of a gas flow through the electrodes in order to describe the showerhead configuration on one hand and surface reactions on the other hand. They express the balance between the net species flux toward the electrode and the net mass of species consumption by surface reactions at the electrode.

This may be written:

$$\begin{aligned} & \left(-D_s \rho \frac{Y_s dx_s}{x_s dx} \right)_{elec} + (u_{d-s} + u_{elec}) (\rho Y_s)_{elec} - (\rho_{feed} Y_{s,feed} \overline{u_{feed}})_{elec} \\ & = (\gamma + \sigma) v_s |_{elec} - w_s^+ |_{elec} \end{aligned} \quad (18)$$

The LHS of equation (18) gathers the flux terms involved in the boundary conditions. The first term of the LHS is the diffusion flux at the electrode. The second term represents the advection flux due to both gas flow (u_{elec}) and drift transport (u_{d-s}) at the electrode. The third term represents the mass flux of species 's' that flows in from the electrode with the feed gas inlet. This term is non zero only at a showerhead electrode, i.e., $u_{feed}|_{elec} \neq 0$, and for argon and acetylene species.

The RHS of equation (18) represents the net loss of species 's' by surface chemistry. The first term represents the loss rate by recombination processes and sticking (deposition) to the electrode surface. $v_s|_{elec}$ is the collision frequency of species 's' per unit area with the electrode, while γ and σ are the recombination and sticking probabilities. We consider that stable species (i.e. Argon, molecular hydrogen and polyynes) are reflected at the wall. Positive ions totally recombine at the wall through dissociative processes ($\gamma=1$) while negative ones are trapped into the bulk and do not interact with the surface. With regard to the radicals, it is well known that the recombination coefficient greatly depends on the processing conditions such as temperature or surface composition [33], [59], [16]. Such variations could greatly impact the deposition process but have limited influence on the discharge dynamics as shown in [60]. Therefore, we have adopted constant values of sticking coefficients. Following the recommendation of [16] small recombination coefficient of 10^{-3} has been used for radicals while values of 1 from [49] have been used for Ar*.

The second term, $w_s^+|_{elec}$ represents the mass production rate of 's' by surface chemistry, i.e. from recombination of other species.

The collision frequency $v_s|_{elec}$ depends on the nature of the species i.e. if it is charged or neutral. For neutral species $v_s|_{elec}$ is obtained from the thermal velocity. The ions however are strongly accelerated in the sheath which significantly enhanced the drift velocity and the collision frequency [61], [62].

It is worthy to mention that the flow velocity at the electrode u_{elec} in equation (18) is different from the inlet velocity of the feed gas u_{feed} . This is due to the fact that the net mass flow at the electrode includes not only feed gas mass flow but also a net mass flux that results from species back-diffusion and surface reactions. Actually, the contribution of the feed gas flow to the boundary conditions (18) appears as a linear source term and not as a flux term. The value of u_{elec} is to be determined from a total mass balance equation at the electrode. Such an equation is obtained by summing equation (18) over all the chemical species. When performing such a summation, the terms corresponding to diffusion fluxes, drift fluxes, mass production rates and recombination rates cancel out. This leads to the following equation that determines the velocity at the electrode:

$$u_{elec} = \frac{\rho_{feed}}{\rho} \cdot u_{feed} - \frac{1}{\rho} \sum \sigma v_s |_{elec} \quad (19)$$

In fact, equation (19) specifies the boundary conditions for the flow velocity at the electrodes and it appears once again that u_{elec} is not necessarily equal to u_{feed} . The use of this equation is of critical importance in order to insure accurate total mass balance and relative predominance of the three elements C/H/Ar.

All the species boundary conditions that should be in principle applied in order to determine the molar fraction of each species at the electrode, $Y_s |_{elec}$, can be derived from equations (18) and (19). The most simple and commonly used boundary condition in the literature [43], [37], [39], may be obtained by neglecting diffusion and drift transport in LHS of equation (18) as well as surface

chemistry in the RHS of this equation and in equation (19), so that $Y_s|_{elec} = y_{s,feed}|_{elec}$. This simplified boundary condition is referred as 'convective'. On the other hand, one can also use a detailed and more realistic species boundary condition that takes into account all the terms in equation (18) and is referred to as 'mixed convection-diffusion-surface reaction' (MCDS) in the rest of the paper. A comparison between these two boundary conditions will be considered in section III.

The last equation for which boundary conditions have to be specified is the electron energy equations. We used classical boundary conditions given in [63].

$$\vec{\Gamma}_{ee|wall} = \begin{cases} \frac{5}{3} \Gamma_e \varepsilon_e - D_e \left(\frac{dn_e \varepsilon_e}{dx} \right) & ; \text{if } \Gamma_e \text{ is directed toward the electrode} \\ \pm \varepsilon_e \sec \gamma_e \sum_i r_i & ; \quad \text{else} \end{cases} \quad (20)$$

II. 7. Solution procedure

The solution of the equations that describe the discharge dynamics, the transport/chemistry of long characteristic time species and the flow velocity component is performed using an iterative procedure. At each iteration step, the discharge dynamic equations, i.e., the species continuity equations for electron and ions, the electron energy conservation equation, the Poisson's equation subject to their boundary conditions, are first time-integrated over several hundreds of RF periods in order to approach the permanent regime. During this first step the densities of neutral species are assumed to be constant. The time-averaged collision frequencies for electron-impact processes required in the LCT module are inferred from this first step. Then, the second step consists in the time-integration of the LCT species continuity equations coupled to the steady state flow velocity equations. Here the coupling between the species and flow equations is of prime importance since the surface reactions play a role in the velocity boundary conditions. The flow velocity equations are solved iteratively so as to adjust the pressure gradient in order to fulfill the boundary conditions on the velocity. This second step is dedicated to LCT species evolution. It will obviously concern the neutral species as well as some ions. As a matter of fact, in some conditions, i.e. high discharge electronegativity, ions may show long time-scale evolutions due to some non-linear slow processes such as mutual neutralization. Actually, it is very difficult to proceed to a complete separation between ions that are treated in the discharge dynamic module and neutral species treated in the LCT module. It is necessary to keep considering all the ions in the discharge dynamic model because even a small change or modulation of the ion density may strongly affect the space charge field and alter the resulting self-consistent field. This double-constraint led us to keep integrating the ion continuity equations in the discharge dynamic module and to introduce for each ion an image-ion that is treated over much longer time scale using the time-averaged continuity equations (Equation (6)). Each image-ion has exactly the same characteristics and undergoes the same chemistry as the corresponding ion. The only difference between an ion and its image is that, the continuity equation is integrated over the RF period time scale for an ion, while time-averaged continuity equation is used for the image-ion. The ion densities in the discharge module are corrected using the image ion density computed in the LCT module along with a convenient under-relaxation.

The iterative procedure described above is carried out until the permanent discharge regime and steady-state for LCT species densities are reached. In such conditions, the time-averaged density of

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3 an ion and the density of the corresponding image-ion should be the same. A special attention was
4 devoted to check this equality which is one of the convergence criteria.
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8 **III. Results and discussion**

9 **III. 1. Considered discharges conditions**

10 One of the main objectives of this study is to analyze the effect of the flow velocity and configuration
11 on the plasma characteristics. We focus on the following discharge conditions: a pressure of $p=10$
12 Pa, an electrode diameter of 20 cm, a gap distance of 2.54 cm, an RF voltage amplitude, $V_{RF}=100$ V,
13 and a molar feed gas composition of 4% acetylene and 96% argon. These conditions are close to
14 those considered in reference [39] and [43].
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16 We will first investigate Ar/C₂H₂ plasma behavior for a showerhead configuration with a flow rate of
17 10 sccm, which corresponds to a flow inlet velocity of 5×10^{-2} m.s⁻¹, assuming purely convective
18 boundary conditions at the showerhead electrode. The details of the transport phenomena and
19 collisional processes that govern energy depositions, ionization kinetics, discharge dynamics and
20 plasma compositions will be thoroughly analyzed for this first base-case. Then, in the second part of
21 the study we will use the more realistic mixed convection-diffusion-surface reaction boundary
22 conditions. We will show how such a change in the boundary conditions affects not only the plasma
23 composition but also the plasma dynamics. Then, we will investigate the effect of the flow velocity
24 on the plasma characteristics under showerhead feed gas configuration. Eventually, comparison
25 between the showerhead and remote feed gas configurations will be carried out.
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34 **III. 2. Convective boundary conditions at the showerhead electrode – acetylene dominated** 35 **discharges.**

36 In this first part we analyze the Ar/C₂H₂ discharge when using a purely convective boundary condition
37 at the showerhead electrode located at $x=0$ m with the mole fractions set to 0.96 for argon, 4×10^{-2}
38 for C₂H₂ and 0 for all other neutral species. The boundary conditions at the other electrode takes into
39 account the surface processes and are given by equation (Equation 18) with $u_{feed}=0$.
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43 The axial profiles of time-averaged electron density and temperature are given in Figure 2. The
44 electron density in the bulk of the plasma is as high as 3×10^{15} m⁻³, a value that is closed to the one
45 measured by Stefanovic et al. [32]. Similar electron density value are also predicted by Ariskin et al.
46 [43] who used a 1D hybrid model and Denysenko et al. [45] who used quasi-homogeneous, i.e., 0D,
47 model. The average electron temperature reaches approximately 4 eV in the plasma bulk and 5 eV in
48 the sheath. These values are in good agreement with those usually reported for Argon discharges
49 under similar conditions [64] and those reported by Greiner et al. [65]. These values are however
50 much higher than those reported by Ariskin et al. [43], i.e. 1 eV in the bulk and 1.6 eV in the sheath.
51 The instantaneous values of electron temperature may be much larger. They reach a peak-value of
52 15 eV in the sheath during the cathodic phase. The average electron temperature shows non-
53 monotonous behavior with a first increase inside the sheath and a decrease very close to the
54 electrode. The temperature variation inside the sheath is well resolved in the simulation, while the
55 steep decrease at the electrode could be hardly resolved even with highly refined mesh.
56 Nevertheless, this has no impact on the simulation results since (i) the temperature variation remains
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3 moderate,(ii) there is very weak ionization and energy dissipation very near the electrode and (iii) the
4 instantaneous electron temperature axial profiles are very well resolved in the sheaths except very
5 close to the electrode during the cathodic phase when the electron density is very small in this
6 region.
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9 These differences may be explained by several factors. The gap size in [43] is much larger than that
10 used in this work, which would result in reduced surface losses. The electron temperature required
11 for sustaining the discharge would be therefore much lower. The second reason is also related to a
12 significant difference in the electron loss rate. As a matter of fact, it seems that Ariskin et al. do not
13 take into account the attachment on large HC which represents a significant electron loss channel in
14 our model. A last reason for this difference is related to the treatment of the electron kinetics in the
15 two approaches. Ariskin et al. make use of hybrid model and a kinetic approach that enables taking
16 into account the stochastic heating effect that results in an enhanced production of high energy
17 electrons. This is not the case in our model where we assume that the eedf satisfies the two-term
18 expansion of the Boltzmann equation, which leads to a collisional depletion of the high energy
19 electron population. As a result the predicted value for the electron temperature necessary for
20 sustaining the discharge obtained from a hybrid model would be naturally smaller than that
21 predicted by a fluid model. Note however that a major difference between the present model and
22 Ariskin et al.'s is related to the central role of argon metastable in the ionization kinetics. It seems to
23 us that electron impact ionization on Ar^* and ionization of C_2H_2 through Ar^* quenching, that
24 represent a major contribution in the overall ionization kinetics in our study, are not taken into
25 account by Ariskin et al. Omitting Ar^* mediated ionization processes should in principle lead to a
26 larger electron temperature. This is obviously not the case here and it seems that even these
27 processes are important, the difference between the electron temperature values predicted by the
28 two models is determined by the assumption made on the eedf and/or the gap distance effect
29 and/or the attachment kinetics. The electron temperature predicted by the present fluid model is
30 also larger than that of Denysenko et al. [45] who used a 0D model with Druyvesteyn eedf. This is in
31 principle similar to the eedf determined in this work by solving the Boltzmann equation. The
32 difference in the electron temperature is therefore more probably due to the difference in the
33 electron loss term that is spatially averaged in Denysenko et al. global model. In any case this
34 discussion shows that comparison between the electron temperature values obtained by the models
35 mentioned above is difficult and many factors may explain the differences observed.
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45 **Erreur ! Source du renvoi introuvable.** 2 shows the power density, in $\text{W}\cdot\text{m}^{-3}$, gained by the electrons
46 from the electric field, W_{RF} , and the power density that the electrons dissipate through collisions,
47 Q_{col} . We observe that the RF power is deposited over a fairly large region extending from the sheath
48 to the bulk of the plasma. The maximum power deposition is however obtained in the regions
49 around the sheath edges, the deposited RF power density is fairly small near the electrodes and in
50 the center of the plasma. We notice that the collisional dissipation power density value, Q_{col}
51 is consistent with the value reported in [43]. It is dominated by the non-dissociative C_2H_2 excitation.
52 The total power deposited in the whole discharge gap is approximately 6 W for an electrode
53 diameter of 20cm. It appears that the power density dissipated by the electrons in collisional
54 processes is much lower than the power they gain from the RF field. Also, the axial profile of the
55 dissipated power density is very different from the RF power deposition profile. It shows a maximum
56 in the center of the discharge and very weak values in the vicinity of the electrodes. This emphasizes
57 the non-local character of electron energy relaxation and the important role of electron energy
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transport as far as the discharge equilibrium is concerned. From Figure 2 we could estimate that only 45 % of the power is dissipated in the plasma chemistry through the collision term Q_{col} . The remaining power is lost by the electron absorbed at the electrodes.

A detailed analysis of the collision term Q_{col} provides the main routes of collisional power dissipation used to sustain the plasma. It turns out that more than 50 % of the collisional power dissipation takes place through the excitation of the argon metastables state. More than 20 % is due to the electronic excitation of C_2H_2 and only ≈ 20 % of this power is used for the electron impact ionization of C_2H_2 and Ar. Actually, the argon metastables plays a key-role in the discharge equilibrium. Figure 4 shows the axial profiles of Ar^* molar fraction calculated in the investigated Ar/ C_2H_2 discharge and in a pristine argon discharge for the same RF voltage, pressure and gap distance. It appears that the metastables density in Ar/ C_2H_2 discharge is two orders of magnitude lower than in pristine Argon discharge, i.e. $8 \times 10^{15} m^{-3}$ and $8 \times 10^{17} m^{-3}$ respectively. This is due to the very fast quenching of Ar^* by C_2H_2 in Ar/ C_2H_2 plasmas. Such a fast quenching was also experimentally observed by [32]. It results in the ionization of acetylene and brings a major contribution to the ionization kinetics and discharge equilibrium. Indeed, this quenching contributes to almost 70% of $C_2H_2^+$ production and is therefore more important than the direct ionization route. The Ar^* density predicted by the present model are comparable to the value measured by Stefanovic et al. [32] who found Ar^* density of $4 \times 10^{15} m^{-3}$ for a $\approx 6\%$ C_2H_2 feed gas. These authors also measured more than one order of magnitude decrease of Ar^* density between Ar/ C_2H_2 and pristine Ar plasma. This trend is consistent with the one obtained from this study although the discharge conditions simulated in this work and investigated in [32] are different.

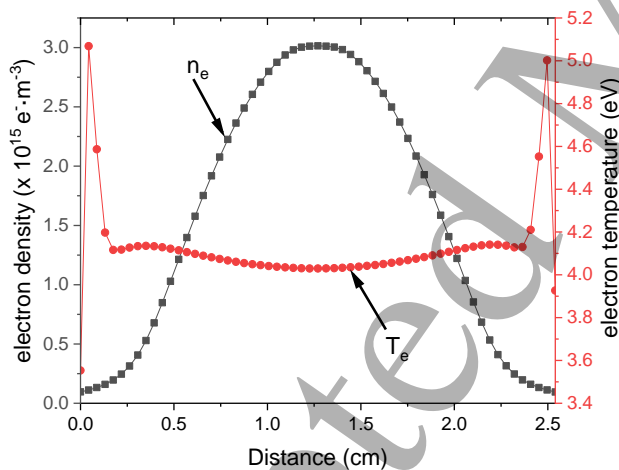


Figure 2: electron averaged density and temperature over an RF period along the discharge for convective boundary conditions

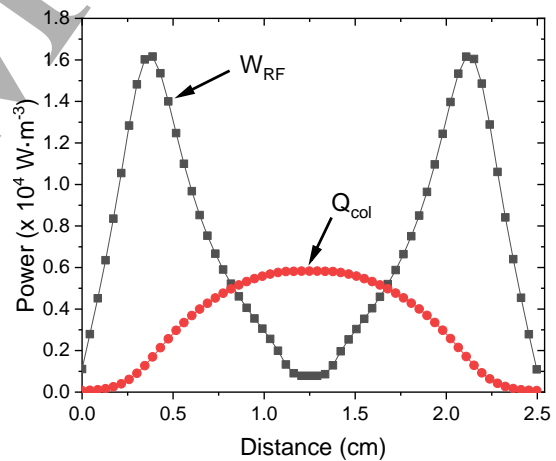


Figure 3: power density transmitted to the electron, W_{RF} and transmitted by the electron to the plasma chemistry, Q_{col} , for convective boundary conditions

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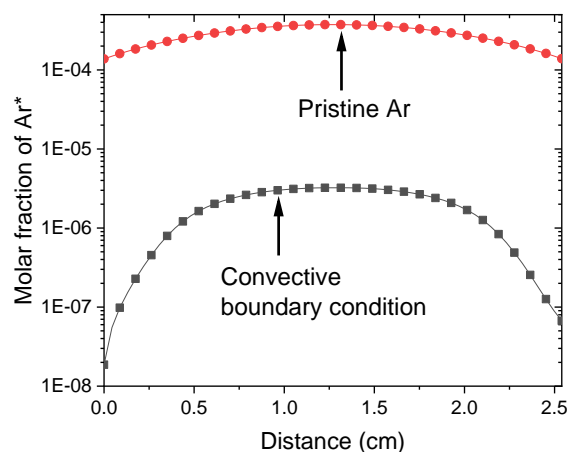


Figure 4 : Argon metastables molar fraction along the discharge in Ar/C₂H₂ and pristine Argon discharges.

Figure 5a shows the axial profiles of the major neutral species. These are C₂H₂, C₂H, H₂ and large hydrocarbon species that have been lumped and denoted C_{x≥4}H_y. It appears that, with the adopted boundary conditions, C₂H₂ mole fraction which is set to 4x10⁻² at the showerhead electrode, x=0 cm, shows only slight decrease along the discharge reaching 3.83x10⁻² at the right electrode, which corresponds to dissociation rate of 4.3%. C₂H₂ remains therefore the main hydrocarbon species. The conversion of acetylene is the first stage of a molecular growth chemistry that ends up with the formation of large hydrocarbon species. The total mole fraction of C_{x≥4}H_y species reaches indeed a value of 5x10⁻⁴ at the right electrode. This is more than one order of magnitude greater than the mole fraction of C₂H which is the main product of acetylene conversion. This clearly shows that once produced, C₂H-radical is rapidly involved in molecular growth processes of the type [37] : C₂H + C_nH₂ → C_{n+2}H₂ + H.

C₂H radical is produced at 29 % by electron-impact dissociation of acetylene, but its production is strongly enhanced by the Ar* quenching on C₂H₂ which represents 71% of the production rate of C₂H radical. This effective production of large hydrocarbon species in Ar/C₂H₂ was also observed experimentally by mass spectrometry [24] and the major role of Ar metastable was experimentally shown by Stefanovic et al [32]. The strong interaction between Ar* and molecular precursors has also been observed in Ar/HMDSO system [66]. A collisional radiative model developed by Garofano et al [66] emphasized the impact of the different precursors on the quenching of argon 1s and 2p states.

Figure 5b shows the detail of the large HC molar fractions. Although the abundance decreases with the carbon number, large HC show significant molar fractions, which is consistent with an effective molecular growth process. The major large HC are in the form of C_{x≥4}H₂ as it was observed in mass spectra of [24].

The other major neutral species are C₂H and molecular hydrogen that shows mole fraction of about 10⁻⁴ at the stagnation electrode. The difference in the boundary conditions specified at the two electrodes results in non-symmetrical axial profiles for the neutral species. Except in the case of acetylene, the neutral species show large depletions in the vicinity of the showerhead electrode and almost no variations in the vicinity of the stagnation electrode. The almost flat mole-fraction profiles in the vicinity of the stagnation electrode show that diffusion/convection transport is much faster than surface chemistry for all the neutral species. In fact, under the investigated conditions, their transport is dominated by diffusion, i.e., their Peclet numbers are fairly small. Therefore the convective boundary condition induces a back-diffusion from the bulk of the plasma where these

neutral species are generated to the showerhead electrode where their mole-fractions are constrained to zero. One of the major consequences of this situation is that the species loss is much more important at the showerhead electrode, i.e., the back-diffusion fluxes are dominant due to the large gradients at the showerhead electrode as compared to the stagnation electrode.

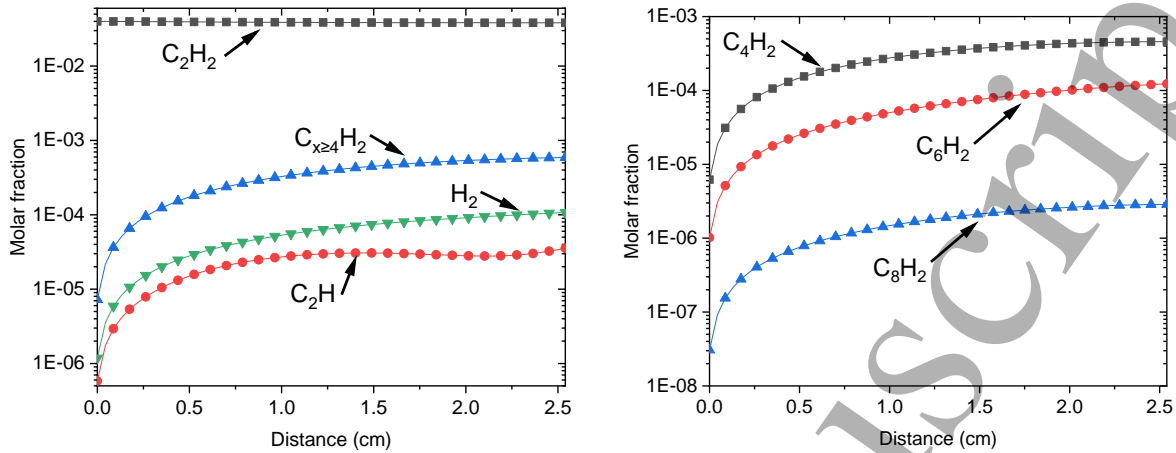


Figure 5 : distribution of (a) H_2 , C_2H , C_2H_2 , and large hydrocarbons (lumped for $x=4,6,8$) and (b) C_4H_2 , C_6H_2 and C_8H_2 along the discharge in Ar/C_2H_2 discharge. for convective boundary conditions

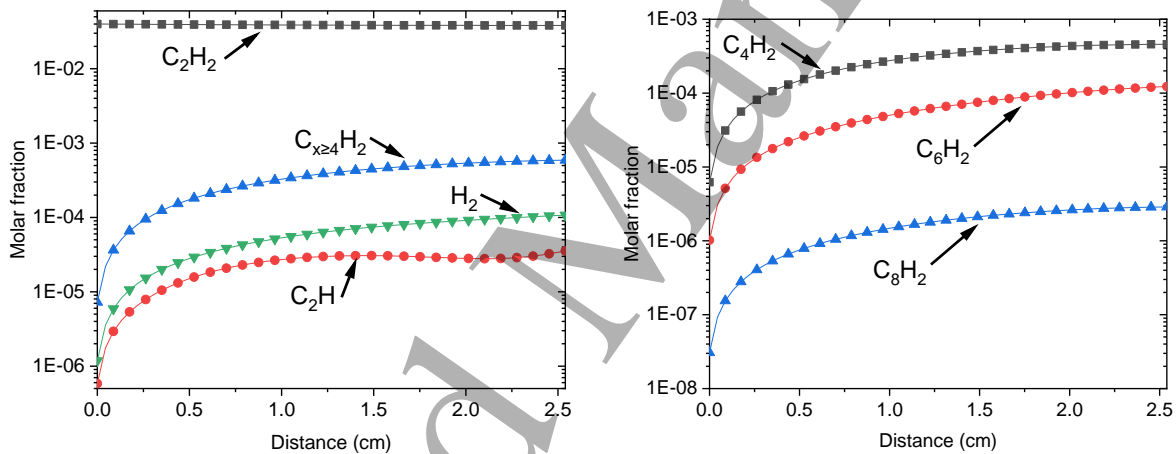


Figure 6 : distribution of (a) H_2 , C_2H , C_2H_2 , and large hydrocarbons (lumped for $x=4,6,8$) and (b) C_4H_2 , C_6H_2 and C_8H_2 along the discharge in Ar/C_2H_2 discharge. for convective boundary conditions

Figure 7a and Figure 7b show the axial profiles of the major positive and negative ions. Ions with four carbon atoms and more were lumped and only their total mole fraction was reported. More detailed information on large hydrocarbon ions may be found in Figure 8. Although argon is by far the dominant neutral species, Figure 7a shows that for the present simulation conditions, Ar/C_2H_2 plasmas are dominated by acetylene ions with concentrations that are two-orders of magnitude larger than that of Ar^+ . This is clearly the consequence of the enhanced acetylene ionization through Ar^* quenching. In fact, this ionization route requires an activation energy that corresponds to the excitation threshold of the first metastables, e. g., 11.56 eV, which is significantly smaller than the energy threshold for electron impact ionization of argon, 15.8 eV. This central role of argon metastables in the ionization kinetics of argon/acetylene plasmas has been also observed experimentally by Stefanovic et al [32].

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3 **Figure 7a** also shows that the positive hydrocarbon ions are subject to a molecular growth despite
4 their fairly limited residence time in the discharge region. As a matter of fact, the total mole fraction
5 of $C_{x \geq 4}H_y^+$ is only two times smaller than $C_2H_2^+$ mole fraction and therefore largely exceeds the
6 concentration of argon ions in the center of the discharge. The mole fraction of these large ions
7 remains significant in the sheaths where they are only fourfold smaller than $C_2H_2^+$ mole fraction.

8
9 **Figure 7b** shows that the negative ions are strongly confined over no more than 5 mm-width region in
10 the discharge bulk and show a very sharp maximum at the center of the gap. The total negative ion
11 density is slightly larger than the electron density and the plasma may be considered as
12 electronegative in a very narrow 5 mm-width region around the gap center. In this region, we also
13 observe a large enhancement of positive mole-fraction with a significant distortion of the
14 corresponding axial-profiles. These profiles show prominent maxima in the electronegative narrow
15 region (**Figure 7a**) so as to balance the large value of negative ions and insure the electrical neutrality
16 in the bulk of the plasma. To the best of our knowledge, such a narrow distortion cannot be observed
17 experimentally. However, similar local peaks have been observed in the simulation of silane dusty RF
18 discharges [67] where the presence of high negative charges carried by solid particles trapped in the
19 discharge enhanced the ion concentration to ensure local quasi-neutrality. This small
20 electronegative region is of prime importance for the discharge equilibrium. This is indeed the only
21 region where the negative-ions can be consumed through mutual neutralization with positive ions. In
22 fact, the analysis of source and flux-divergence terms in the balance equations shows that negative
23 ions are equally produced overall the discharge gap, transported to the discharge center where they
24 are confined and then consumed by mutual neutralization with positive ions. Some of these
25 processes are fairly long. For instance, the mutual neutralization and transport phenomena show
26 characteristic times of 10 and 10^{-2} ms, respectively. This is much larger than the RF period, which
27 clearly shows the stiffness of the system and the interest of the solution procedure proposed in this
28 work. This enables to solve for both the very fast discharge dynamics and the fairly slow processes.
29 Outside the electronegative region at the center of the gap, the plasma is electropositive and the
30 discharge equilibrium is governed by the balance between acetylene and argon ionization processes
31 on one hand, and electron and positive ions losses at the electrodes on the other hand. **Figure 7b**
32 shows that the concentration of large negative ions is also significant. It is even slightly larger than
33 that of C_2H^- . This shows that negative ions also experience molecular growth processes in the narrow
34 electronegative region.

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36 The axial profiles of charged species are perfectly symmetric despite the difference between the
37 boundary conditions specified at the showerhead and the stagnation electrodes. This may be easily
38 understood for negative ions that are confined in the center of the discharge and that are not
39 sensitive to the nature of the boundary conditions specified at the electrodes. As for the positive
40 ions, the density in the sheath near the electrodes is mainly governed by drift fluxes, i.e., diffusion
41 can be neglected and ionization is very weak inside the sheath. The high drift velocity of the positive
42 ions combined with their total recombination at the wall result in very small density-values at the
43 electrodes. In fact, the difference in the boundary conditions results in only very slight differences
44 between the ion densities at the two electrodes which can be hardly seen on the axial profiles shown
45 in **Figure 7a**.

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47 The details of the large positive hydrocarbon ions are shown in **Figure 8a**. It appears that the density
48 of positive ions decreases by two orders of magnitude when the ion size increases from $x=4$ to $x \geq 8$
49 carbon atoms. This shows that the fairly short residence time of the positive ion does not allow an
50 effective molecular growth of these species. The situation is different for negative ions. In this case
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significant population is obtained even for the largest size, i.e., $C_{x \geq 8}H^-$. Figure 7b shows mole-fraction axial profiles for large negative ions with different sizes. It appears that $C_{x \geq 8}H^-$ mole fraction remains significant and only three times smaller than C_2H^- mole-fraction. These results are in good qualitative agreement with experimental mass spectrometry measurements by [48], [24], [44] which observed maximum amplitude for even carbon atom numbers species. Moreover the decreasing trend as function of mass was also observed. Jiménez-Redondo et al. [68] performed mass spectrometry measurements on an Ar/ C_2H_2 plasma at 10Pa and for an electrode gap of 3cm, which is similar to our conditions, and reveal the same decreasing trend as function of the mass for both positive and negative ions. Their experimental work was coupled with a 0D model which predicts a cation density of $8.8 \times 10^{14} m^{-3}$ that is also in good agreement with the one obtain in our simulations (i.e. $1.2 \times 10^{15} m^{-3}$ in the plasma bulk).

In the solution procedure used in this work the ions axial profiles are determined in both the discharge module and the LCT module. Our methodology would be valid only if the time averaged mole fraction calculated in the discharge module for each ion is in agreement with the mole fraction value obtained in the LCT module for the corresponding twin-ion. Figure 9a shows for illustration comparison between the axial profiles of three pair of ion/twin-ion mole-fraction. It appears that these axial profiles are in very good agreement. This validates our methodology that enables taking into account the coupling between the discharge dynamic and the long characteristic time ion kinetic and transport. Further, Figure 9b shows the comparison between negative ion density distributions obtained from the only time-integration of the discharge dynamic equations over 1000 RF period, i.e. 0.1 ms, and those using the simulation procedure developed in this work. Approximately 20 iterations between the discharge dynamic module and the LCT module were carried out in this last case. It clearly appears that the negative ion density obtained from the only integration of the plasma dynamic equations is still evolving in the discharge gap. It shows values that are two orders of magnitude higher than those obtained when the time-averaged transport module is used. Actually, reaching a quasi-permanent regime for negative ions would require the time-integration of the discharge dynamic equations during more than 10^5 RF periods, which is practically unaffordable. It is also consistent with experimental findings of [69]. Such results may have a significant impact on the predicted molecular growth kinetics of the negative ions and the subsequent particle nucleation route.

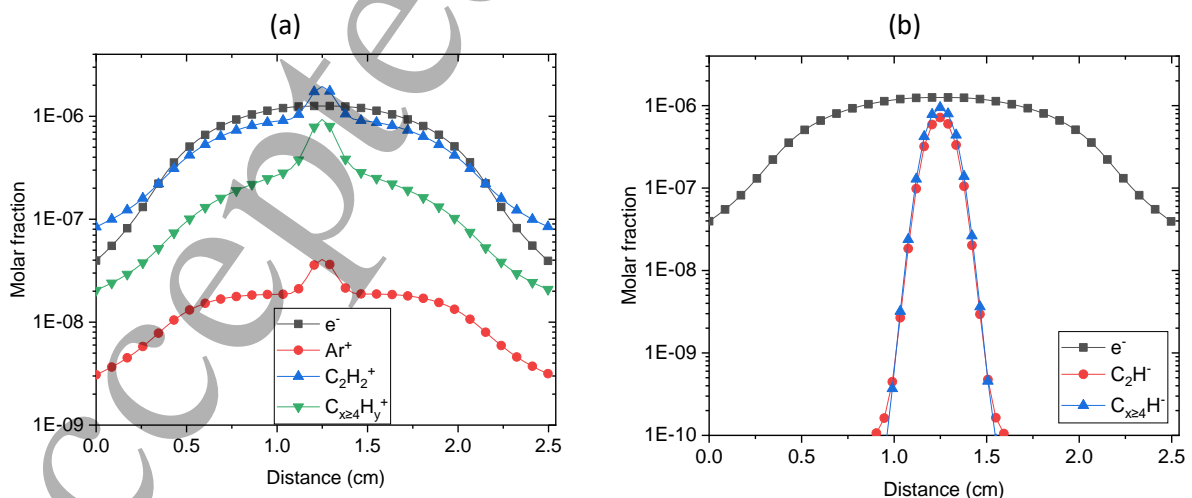


Figure 7: (a) e^- , Ar^+ , $C_2H_2^+$ and larger cations and (b) e^- , C_2H^- and larger anions axial profiles for convective boundary conditions.

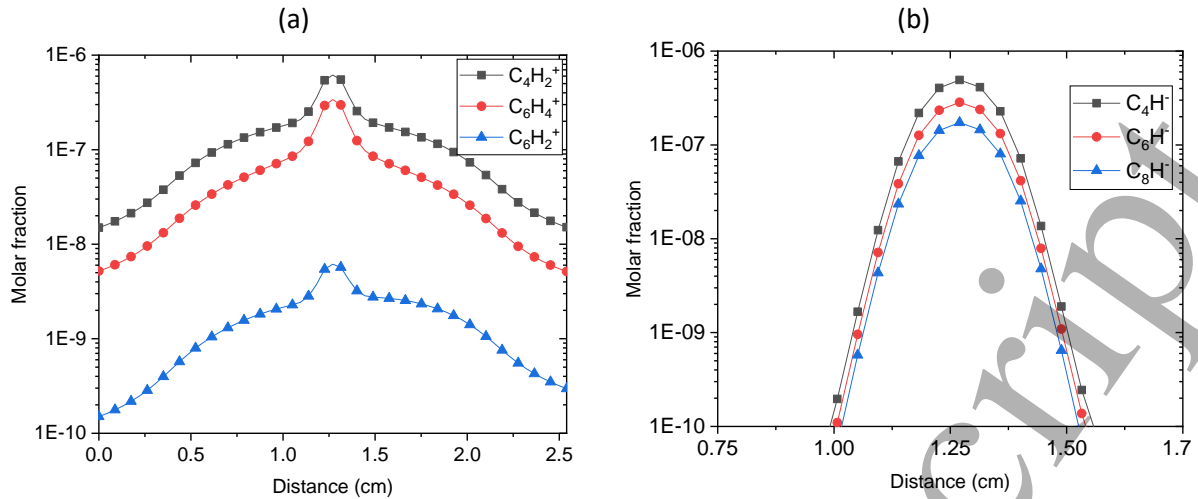


Figure 8 : Axial profiles of (a) the major positive ions and (b) the major negative ions for convective boundary conditions.

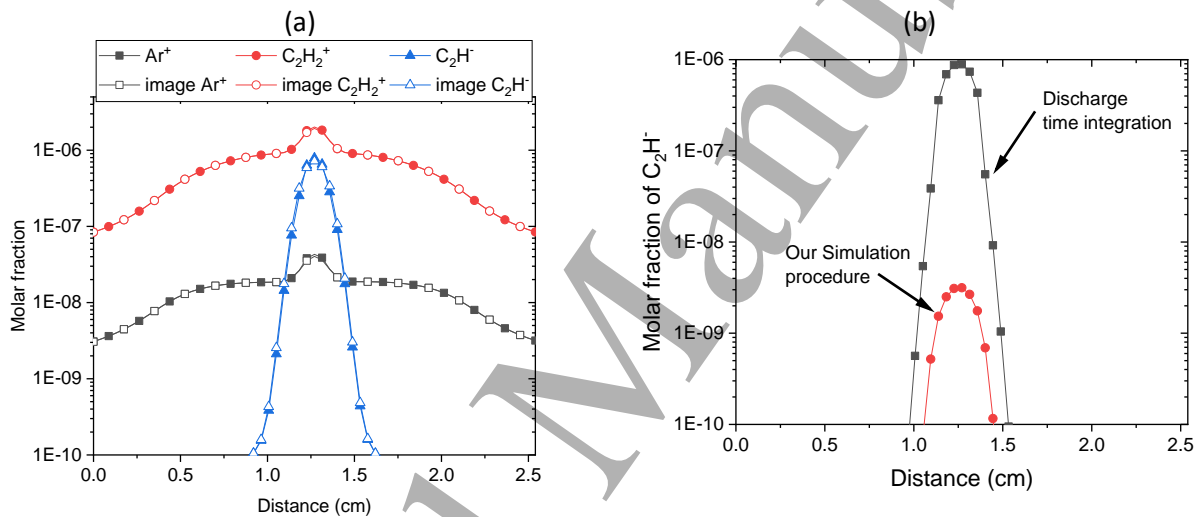


Figure 9 : Comparison of axial profiles for (a) ion and image-ion axial profiles for Ar^+ , C_2H_2^+ and C_2H^- and (b) C_2H^- obtain after long time discharge integration and our simulation procedure.

The use of convective boundary conditions allows investigating the discharge dynamics and the plasma kinetics in the simple case where the hydrocarbon species are dominated by acetylene (the precursor species). We particularly showed that even with small acetylene concentration in the feed gas (4% in the present case), the central region of the discharge is electronegative, a significant molecular growth is observed on both neutral and charged species, and the ionization kinetics is dominated by quenching processes where argon metastables plays a key-role which confirms the experimental observation of Stefanovic and al [32]. Therefore we investigated the impact of the adopted values for the Penning branching ratio on the discharge composition. Using a value of 0.3 instead of 0.7 results in a decrease of C_2H_2^+ and all the positive ions by less than a factor 2 and an equivalent increase of C_2H . Taking into account the complexity of the model, these variations can be considered as quite limited and do not impact the observed trends and conclusions.

The simulations performed using the convective boundary conditions do not enable reproducing the large acetylene conversion that has been observed in many experiments on CCRF discharges [24],[25]. In fact, under the low Peclet transport conditions, imposing the feed gas composition at the showerhead electrode ensures an additional incoming diffusion flux of acetylene that is much larger

than the convective flux generated by the gas flow. In fact, the diffusion is fast enough to insure an almost constant acetylene concentration in the plasma. Of course, this concentration that is almost the same as in the feed gas, is likely to be substantially overestimated. For this purpose, we need to use the more realistic mixed convection-diffusion-surface reaction (MCDS) boundary conditions. This will be discussed in the next sub-section.

III. 3. Mixed convection-diffusion-surface reaction boundary conditions at the showerhead electrode – effect of gas flowrate on the discharge dynamics and plasma composition.

a) **Influence of the boundary conditions on the discharge dynamics and plasma composition in the showerhead configuration**

Simulations were then carried out with the MCDS boundary conditions (Equation 18) specified at the two electrodes with 5 values of u_{feed} , i.e., 5×10^{-2} , 0.1, 0.25, 0.5 and 1 m.s^{-1} , at the showerhead electrode located at $x=0 \text{ m}$ and $u_{elec}=0$ at the stagnation electrode located at $x=2.54 \text{ cm}$.

Figure 10 show the axial profile of the electron density, the electron temperature and Ar metastable for the two types of boundary conditions applied to the neutral species at the showerhead electrode. We observe that the values of electron density and temperature obtained with MCDS boundary conditions at large flowrates, typically between 0.5 and 1 m.s^{-1} , are similar to those obtained with convective boundary condition. However, bulk value of Ar* molar fraction is slightly smaller for convective boundary condition. This smaller Ar* molar fraction values is due to the artificially imposed constraint $Y_{Ar^*}|_{elec} = 0$ in the case of convective boundary conditions..

Figure 10a shows the axial profiles of the acetylene mole-fraction in the gap for the different values of the feed gas inlet velocity along with the distributions obtained with the convective boundary conditions. We observe that when MCDS physical boundary conditions are imposed, the obtained acetylene mole-fraction in the plasma is much smaller than the corresponding feed gas value, i.e. 4×10^{-2} , and also smaller than the values obtained using the convective boundary conditions. Its value in the bulk of the plasma decreases from 2×10^{-2} for $u_{feed}=1 \text{ m.s}^{-1}$ to 10^{-4} for $u_{feed}=5 \times 10^{-2} \text{ m.s}^{-1}$. These results show that acetylene is in fact highly converted in the acetylene/argon plasma investigated here. Figure 10b shows the conversion yield of acetylene, defined as $\frac{C_{2H2_{feed}} - C_{2H2_{plasma}}}{C_{2H2_{feed}}}$, as a function of the inlet feed-gas flow velocity. Even with a fairly high inlet velocity-value, i.e., $u_{feed} = 1 \text{ m.s}^{-1}$, corresponding to very short residence time in the gap, i.e., $\tau_{res}=700 \text{ ms}$, 50% of acetylene is converted. The conversion yield is as high as 90% for an inlet velocity smaller than 0.35 m.s^{-1} and becomes almost total, i.e. $\approx 100\%$, for a flow velocity smaller than 0.25 m.s^{-1} .

Conversion yields greater than 90% were also measured in [32], [24],[25] for acetylene in Ar/C₂H₂ plasmas. Such total conversion yields were also predicted in the plasma bulk using a global 0D modeling by Denysenko et al [44] and by Ariskin et al. [43] who used a hybrid approach. Such large conversion yields of the precursor are also consistent with many experimental results observed in other Ar/molecular precursor systems such as Ar/HMDSO [66].

The acetylene mole-fraction shows very small space variation in the gap except in the case of very small inlet velocity values. This means that diffusion transport is fast enough to induce an effective

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3 mixing and an almost uniform acetylene concentration. In fact, this fast diffusion explains the
4 difference between the acetylene fractions obtained with the convective and MCDS boundary
5 conditions. In the case of MCDS boundary conditions, the constraint on the acetylene concentration
6 at the showerhead electrode is relaxed and the overall acetylene concentration in the feed gas is
7 determined by the balance between the amounts of acetylene introduced into the reactor and
8 converted in the discharge. As a consequence, acetylene mole fraction at the showerhead electrode
9 is much smaller than the feed gas values since acetylene is highly converted in the bulk and C_2H_2
10 diffuses from the inlet to the central region where C_2H_2 is converted. Therefore, the application of
11 MCDS physical boundary conditions is absolutely required for a satisfactory description of discharge
12 conditions with large acetylene conversion yields.
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16 **B) Influence of the flowrate on the discharge dynamics and plasma composition in the** 17 **showerhead configuration**

18 One can deduce the effect of flowrate on the electron temperature and density, argon metastable
19 from Figure 10. It appears that the electron mole-fraction in the bulk of the plasma increases by
20 more than a factor 4, i.e. from 0.3×10^{-6} to 1.3×10^{-6} , when u_{feed} increases from 0.05 to 1 $m \cdot s^{-1}$. On the
21 other hand, the electron-temperature shows an opposite trend and decreases by 1 eV, from 5 eV to
22 4 eV, for the same flow velocity variation. The effect of u_{feed} is even more pronounced on argon
23 metastables, the bulk mole fraction of which decreases by two orders of magnitude, i.e., from 10^{-4} at
24 $5 \times 10^{-2} m \cdot s^{-1}$ to 10^{-6} at 1 $m \cdot s^{-1}$. From Figure 10 a, it appears that when the flow velocity is decreased
25 by a factor 20, the acetylene mole-fraction in the plasma decreases by a factor 400. The change in
26 acetylene concentration with the flow velocity (or residence time) is therefore non-linear and most
27 of the acetylene conversion yield variation takes place over the inlet velocity range 0.25-1 $m \cdot s^{-1}$. As a
28 matter of fact, the conversion yield increases from 45% at 1 $m \cdot s^{-1}$ to 95% at 0.25 $m \cdot s^{-1}$. Further
29 decrease of the inlet velocity results in a very slight change of the conversion yield since acetylene is
30 already almost totally converted at 0.25 $m \cdot s^{-1}$.
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39 A close look to 10 reveals that the bulk-values for electron density, electron temperature and argon
40 metastables density exhibit two slight variation domains at large and low inlet velocity separated by
41 a sharp transition around 0.25 $m \cdot s^{-1}$. For instance, the bulk electron mole-fraction shows less than
42 10% relative variation in the inlet velocity ranges 0.5-1 $m \cdot s^{-1}$, a sharp threefold decrease in the
43 velocity range 0.1-0.5 $m \cdot s^{-1}$ and around 20% relative variations in the velocity range 0.05-0.1 $m \cdot s^{-1}$.
44 Actually, this behavior corresponds to a transition between two ionization regimes (cf. Figure 10). In
45 the first one, obtained for a gas flow velocity in the range 0.25-1 $m \cdot s^{-1}$, the Penning ionization of C_2H_2
46 by Ar^* strongly dominates the ionization kinetics, which leads to an enhanced production of $C_2H_2^+$,
47 and the discharge is largely dominated by hydrocarbon ions. In the second regime obtained for inlet
48 flow velocity below 0.25 $m \cdot s^{-1}$, electron impact ionization of Ar^* becomes dominant and leads to an
49 enhanced production of Ar^+ . Figure 10 shows that this transition corresponds to more than two
50 orders of magnitude variations in the ionization frequencies of the above mentioned ionization
51 routes. Further, while the increase of the frequency of Penning ionization of C_2H_2 by Ar^* is directly
52 linked to the increase in the acetylene density (cf. Figure 11), the frequency of ionization by electron
53 impact on Ar^* is correlated to the change of electron density and temperature, i.e., $\nu_{Ar^*-e} = k_{i-Ar^*}(T_e)n_e$.
54 It appears that the change in electron impact ionization frequency with the inlet flow velocity is
55 determined by the electron temperature variation. As a matter of fact, both electron-temperature
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3 and ionization frequencies decrease with increasing u_{feed} , while the electron density as well as the
4 power coupled to the discharge (3.6 W for $u_{feed}=0.05 \text{ m.s}^{-1}$ and 6 W for $u_{feed}=1 \text{ m.s}^{-1}$) increases with
5 the same parameter. It appears therefore that the change in the discharge parameters, i.e., n_e , T_e and
6 Ar^* density with u_{feed} is not due to residence time effect as in the case of acetylene conversion, but
7 rather to the change in the ionization kinetics, discharge dynamics and power coupling with the level
8 of acetylene in the plasma.
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11 It is worthy to mention here that the contribution of acetylene to the ionization kinetics remains
12 significant even for flow velocity conditions leading to very small amount of acetylene. This may be
13 clearly observed in Figure 13.a and 13.b that show the axial profiles of the major positive ion mole
14 fractions for flow velocity values of 0.05 m.s^{-1} and 1 m.s^{-1} , respectively. Especially, C_2H_2^+ mole fraction
15 is approximately 1.2×10^{-7} in the bulk of the discharge, which is only 2 times lower than Ar^+ mole-
16 fraction for $u_{feed}=5 \times 10^{-2} \text{ m.s}^{-1}$, a condition for which the C_2H_2 fraction is 10^{-4} . The situation is very
17 different for $u_{feed}=1 \text{ m.s}^{-1}$ when acetylene fraction in the plasma remains significant. In this case, both
18 C_2H_2^+ and large hydrocarbon ions dominate the discharge, while argon ion fraction is more than one
19 order of magnitude smaller. The large hydrocarbon positive ions are much more sensitive to the flow
20 velocity than C_2H_2^+ . The population of these ions increases with u_{feed} and varies by more than three
21 orders of magnitude in the investigated range of flow velocity. The HC positive ion abundances
22 obtained in this study present some discrepancies with the previously simulated ion densities [44]
23 and [43]. As a matter of fact Ariskin et al. [43] predicted a much larger Ar^+ and large HC ion densities.
24 We believe that the difference with our results is due to the fact that the ionization of HC species
25 through Ar^* was not considered in [43], while these processes represent the main ionization route in
26 our conditions. Denysenko et al. [44] obtained C_4H_2^+ as the major ion which is also different from the
27 prediction of our model. This may be explained by the difficulty of evaluating ion fluxes at the
28 electrodes in a global model which may impact the rate of surface losses which are the major
29 consumption term in the balance equation of positive ions in our model. Note however that our ion
30 densities distribution at high flowrate are fully consistent with the ions mass spectrum presented in
31 [44] as C_2H_2^+ is the major species, followed by large HC ions and a much smaller Ar^+ relative
32 abundance.
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40 As for negative ions shown in Figure 13.c and 13.d, flow conditions leading to larger acetylene
41 amount in the plasma, e.g., $u_{feed}=1 \text{ m.s}^{-1}$, results in an enhanced attachment kinetics and an almost
42 two orders of magnitude larger negative ions concentration. As a result, the plasma shows a
43 significant electronegativity for large flow velocity conditions. In this case the discharge structure is
44 similar to the one obtained with the convective boundary conditions discussed in the previous
45 section with a very narrow, i.e., 5 mm width, electronegative region in the plasma bulk surrounded
46 by a much larger electropositive region. Note however that, as in the case of positive ions, the
47 concentration of negative ions remains significant and almost equal to the electron concentration in
48 the bulk of the discharge even for low flow rate conditions when the acetylene fraction is as low as
49 10^{-4} . The evolutions of the negative ion density with the ion size obtained in our model show the
50 same trends as those reported in [45] and [43]. However, our model predicts larger negative ion
51 density, i.e. at least one order of magnitude, and a higher electronegativity in the very center of the
52 discharge gap. It is very difficult to explain such differences. A possible explanation would be the
53 differences in (i) the gap distance (ii) the attachment kinetics (attachment on large molecules) and/or
54 (iii) the prediction of the long characteristic time negative ion transport dynamics and mutual
55 recombination.
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Beside acetylene, the major neutral hydrocarbon species obtained in the discharge are C_2H -radical and large $C_{x \geq 4}H_y$ species, the axial distributions of which are depicted in Figure 14. The concentration of C_2H radical is only slightly affected by the gas flow velocity. Basically, although its axial profile shows significant variation, the bulk C_2H concentration shows the same order of magnitude, $\approx 10^{-5}$, for all the investigated flow velocity values. On the opposite, the production of large neutral hydrocarbons is strongly enhanced for large flow velocities and the $C_{x \geq 4}H_y$ fraction increases from 10^{-6} to 3×10^{-3} with u_{feed} in the investigated range of this parameter. We note however that H_2 mole-fraction is almost constant, of the order of 10^{-2} , for all the investigated flow conditions. Molecular hydrogen may become the major neutral species in the discharge. It is indeed produced by C_2H_2 conversion as well as deposition and molecular growth processes. Although each of these processes changes with u_{feed} , the balance of the overall production rate of H_2 remains almost constant in the investigated conditions. At large flowrate these results are consistent with the mass spectrum measured by [44].

The results obtained show that large flow rate conditions yield much greater densities of charged and neutral large hydrocarbons, which would indicate that nucleation kinetics should be enhanced for the flow velocity range investigated in this work.

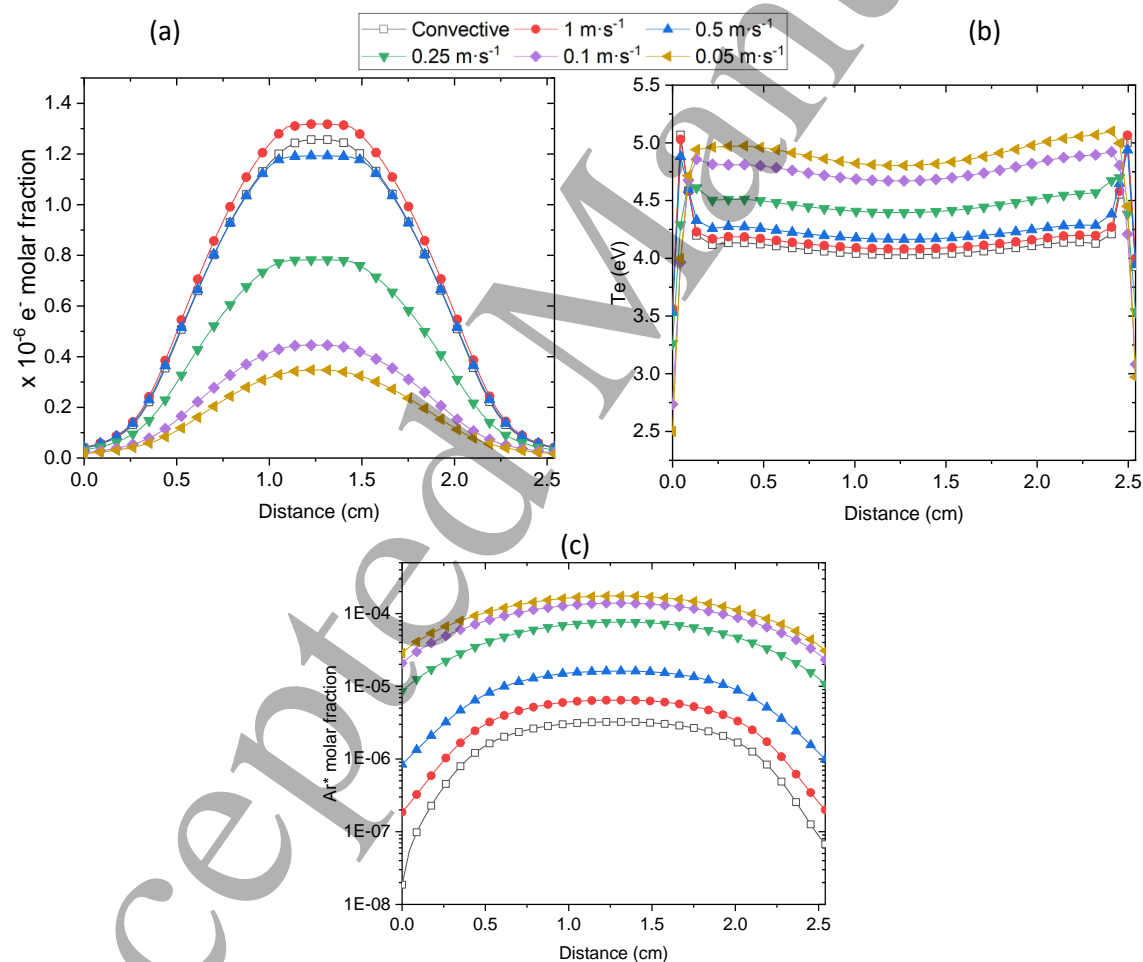


Figure 10: Axial profiles of electron mole fraction (a), electron-temperature (b) and argon-metastables (c) in the gap for different inlet flow velocity-values.

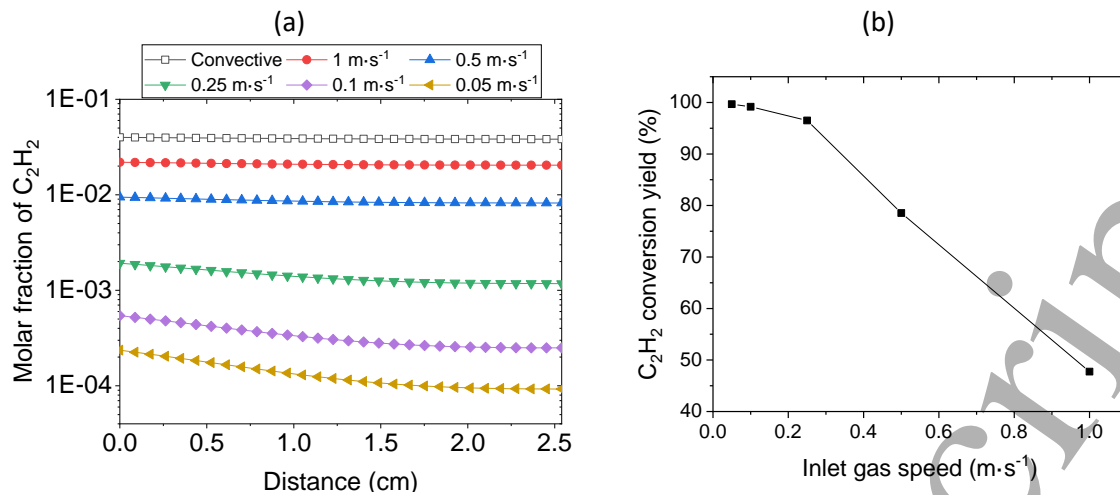


Figure 11: (a) Axial profile of acetylene mole fraction in the gap for convective (blank square) and MCDS (solid symbol) boundary conditions with different inlet flow velocity-values and (b) corresponding acetylene conversion yield as a function of the inlet flow velocity.

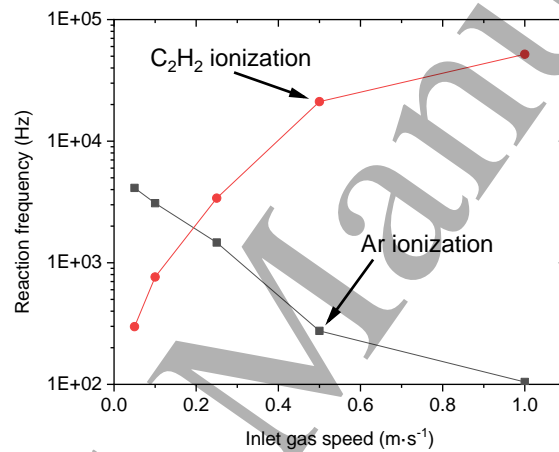


Figure 10 frequency of Penning ionization of C_2H_2 by Ar^* and electron-impact on Ar^* as function of inlet flow velocity value in MCDS boundary conditions.

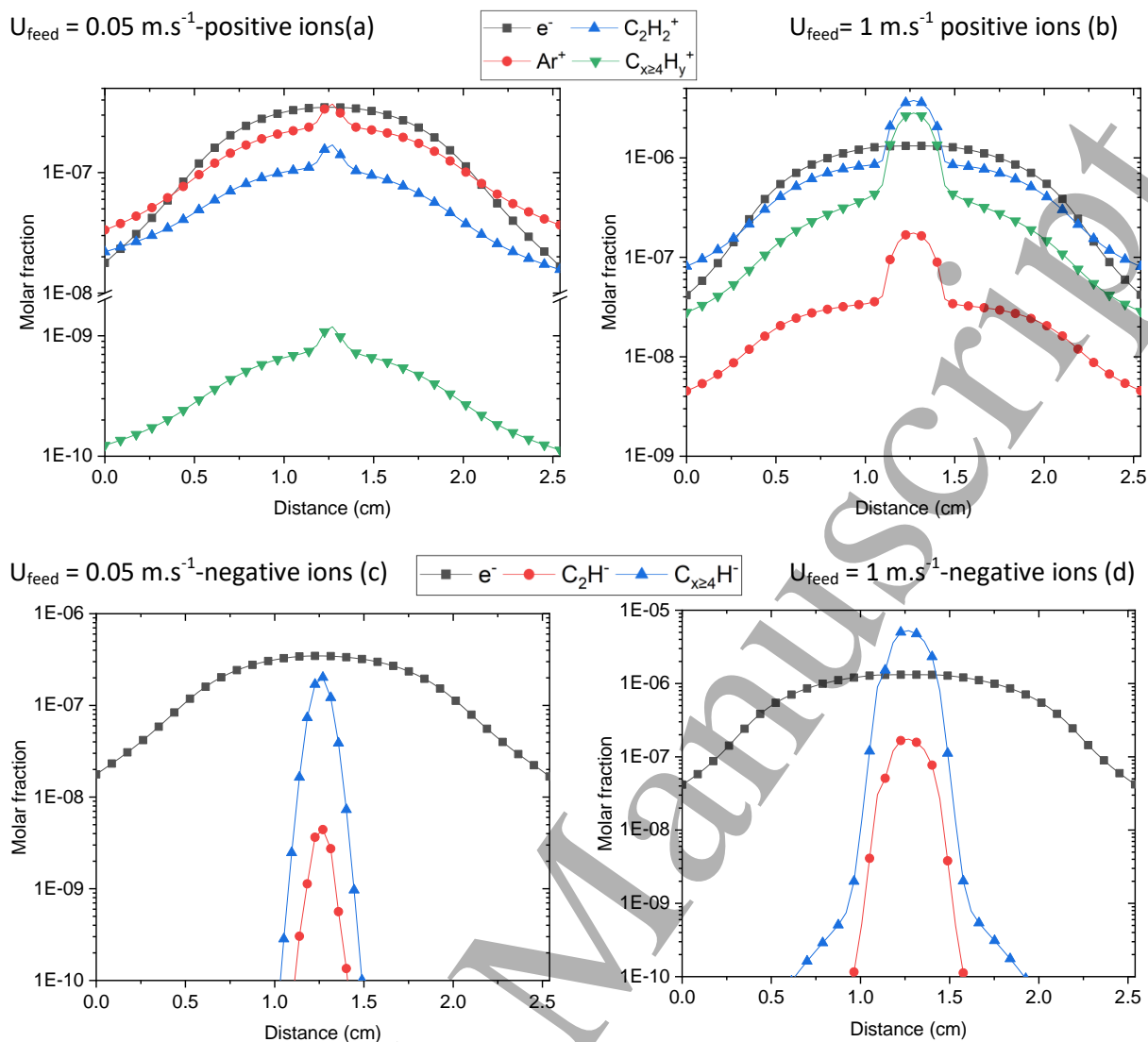


Figure 13: axial profiles of the major positive and negative ions in the discharge gap for the two discharge regimes using MCDS boundary conditions with inlet flow velocity of $5 \times 10^{-2} \text{ m.s}^{-1}$ and 1 m.s^{-1}

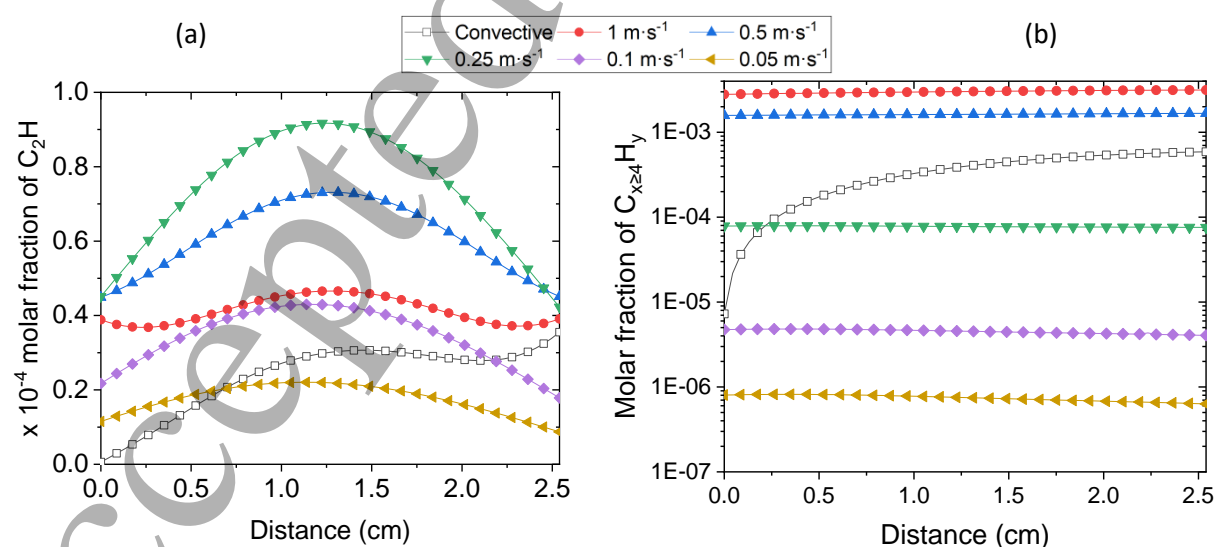


Figure 14: C_2H radical (a) and large hydrocarbon (b), i.e., $C_{x \geq 2}H_y$, mole-fraction in the gap for convective (blank square) and MCDS (solid symbol) boundary conditions with different inlet flow velocity-values

III. 4. Effect of the flow configuration on the discharge dynamics and the plasma composition: comparison between showerhead and remote feed gas systems

In this section we compare the plasma composition and discharge dynamics obtained for the showerhead feed gas inlet discussed in the previous section and the remote feed gas configurations. As discussed in section II. 3., we propose to analyze the plasmas obtained for two asymptotic situations. The first one where $\delta = \frac{V_{gap}}{V_{reactor}} \rightarrow 1$ corresponds to a situation where the discharge gap is directly and homogeneously fed by the fresh gas while the plasma products exit the discharge gap with the gas flow. The second case, where $\delta \rightarrow 0$, corresponds to a full dilution of the discharge products in the reactor volume that shows the same composition as the feed gas. In both situations the flow effect appears as a source term in the species equations. This source term does not depend on the flow rate when the dilution is important, i.e., $\delta \rightarrow 0$. In this case, the flow effect is formulated as a mass transfer phenomenon between the discharge gap and the surrounding post-discharge reactor volume. Therefore, only a single simulation is performed for this case. For the $\delta \rightarrow 1$ case, we performed two simulations $\delta \rightarrow 1@10$ sccm and $\delta \rightarrow 1@100$ sccm. These two values of the flowrate correspond to flow inlet velocities of $0.05 \text{ m}\cdot\text{s}^{-1}$ and $0.5 \text{ m}\cdot\text{s}^{-1}$ in the case of the showerhead configuration.

Figure 15.a and 15.b show the axial profiles of the major neutral species. As in the case of the showerhead configuration, smaller flowrate results in an enhanced acetylene conversion. The acetylene mole fraction decreases by more than two orders of magnitude when the flowrate is decreased from 100 sccm to 10 sccm. This trends is fully consistent with the results obtain for the showerhead configuration, although a factor two difference exists in the absolute mole fraction of acetylene between the two configurations for the large flowrate case. The increase of acetylene conversion for small flowrates does not benefit to the formation of the other hydrocarbon species. For instance Figure 15.a and 15.b show that both C_2H_2 and $\text{C}_{x>4}\text{H}_y$ mole fractions increase with the flowrate. The mole fraction variations for the large hydrocarbon molecules are of the same order of magnitude as for acetylene and much more significant than for C_2H radical. It appears therefore that at low flowrate, the major fraction of C_2H radicals produced by the enhanced C_2H_2 dissociation undergo surface reaction, and deposition is favored over molecular growth (which is a second order process). This trend is also consistent with the results obtained with the showerhead configuration. The most striking difference between the two studied configurations is observed on molecular hydrogen mole fraction for large flowrates. As a matter of fact, while H_2 fraction remains around 10^{-2} for showerhead configuration, values as high as 0.1 are obtained for remote feed gas inlet configuration at 100 sccm. To understand this difference the mass balance of hydrogen needs to be considered. Hydrogen is produced by acetylene conversion in the discharge gap and is mainly lost with the discharge products out-flowing the discharge gap. While the production rates of H_2 are similar, hydrogen loss terms show a large difference between the two configurations. As a matter of fact, the rate of the radial convective losses in the stagnation line theory, i.e., the term $\rho Y_s \frac{du}{dx}$ in equation 15, results in much larger flow induced loss rate values than those estimated on the basis of a uniform gas flow exiting the discharge volume, i.e., the term $\frac{Q_m^{out} Y_s}{V_{plasma}}$ in equation 17, used in the remote feed gas configuration with $\delta \rightarrow 1$.

Although the acetylene inlet fluxes used in the $\delta \rightarrow 0$ and $\delta \rightarrow 1@100$ sccm cases are pretty similar, the C_2H_2 mole-fraction obtained at large dilution, i.e., $\delta \rightarrow 0$, is one order of magnitude smaller (Figure

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3 15c) which indicates that the acetylene conversion is greater. This is related to the large difference
4 between the hydrogen mole fraction values obtained in the two cases, i.e., 10^{-3} and 10^{-1} , respectively.
5 As a matter of fact, the much lower hydrogen content in the $\delta \rightarrow 0$ case results in a smaller energy
6 dissipation, a higher electron density, an enhanced Ar^* production and a subsequent larger C_2H_2
7 conversion. Note that as mentioned previously, this difference in molecular hydrogen contents is
8 due to the difference between the rates of hydrogen loss with the gap outflow in the two models.
9

10 In any case, this shows that large dilutions, i.e., small discharge gap to reactor volume ratios, or large
11 flowrates lead to acetylene dominated ionization kinetics with $X_{\text{C}_2\text{H}_2}$ typically above 10^{-3} . On the
12 opposite small dilutions and flowrates result in argon dominated ionization kinetics and very small
13 acetylene concentrations, typically $X_{\text{C}_2\text{H}_2} \approx 10^{-4}$. The large hydrocarbons follow the same trends as
14 acetylene while small radicals, such as C_2H , shows fairly moderate variations as function of the
15 flowrate or the discharge to the reactor volume ratios.
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17 This change in acetylene fraction has a strong effect on the discharge dynamics, as well as the
18 ionization and attachment kinetics. When decreasing the flowrate, the discharge dynamic transitions
19 from a situation where charged species are dominated by C_2H_2^+ and $\text{C}_{x \geq 4}\text{H}_y^+$ and where the
20 attachment is significant to a situation where the dominant ion is Ar^+ and the attachment is
21 negligible. This may be clearly seen in Figure 16 and Figure 17 that show the axial profiles of positive-
22 ion and negative-ion mole-fractions, for the three cases discussed in this section. As in the case of the
23 showerhead electrode, an enhanced ionization with larger electron mole-fraction (a factor of 2) and
24 significantly smaller electron temperature (δT_e of 1eV) is observed at large flow rate (b) and for large
25 dilution (c), i.e., $\delta \rightarrow 0$. In these cases the discharge is strongly electronegative in a localized region
26 around the mid-gap (Figures 16b, 16.c 17.b and 17.c). The electronegativity in this region is insured
27 by the large hydrocarbon negative ions that show a large density, a factor 5-8 larger than electron
28 density and two orders of magnitude larger than the C_2H^- density (Figures 17.b and 17.c). The
29 situation is different for the positive ions since although large hydrocarbon ions are significant, C_2H_2^+
30 also shows large densities (Figure 16.b and 16.c) and even becomes the major ion with densities that
31 exceed those of $\text{C}_{x \geq 4}\text{H}_y^+$ by one order of magnitude for large dilution, i.e., $\delta \rightarrow 0$ (Figure 16.c). As in the
32 case of the showerhead configuration, the plasma is electropositive and dominated by hydrocarbon
33 ions outside this narrow electronegative region, i.e., both C_2H_2^+ and large HC in the case $\delta \rightarrow 1 @ 100$
34 sccm and C_2H_2^+ for $\delta \rightarrow 0$ (Figure 16.b and 16.c and Figure 17.B and 17.c). For small flow rates, i.e., 10
35 sccm, the discharge is electropositive and dominated by argon ions, although the population of C_2H_2^+
36 remains significant and only a factor 2 below Ar^+ population. This result is quite remarkable: the
37 contribution of acetylene to the ionization kinetics remains highly significant despite its very low
38 concentration, i.e., 10^{-4} , in the discharge. In fact acetylene depletion at low flowrate has much more
39 impact on the large hydrocarbon ions, the concentration of which decreases by more than three
40 orders of magnitude when acetylene is depleted. On the opposite, even though the discharge
41 becomes electropositive, the large negative-ion density remains fairly large and of the same order of
42 magnitude as the electron density at low flowrate.
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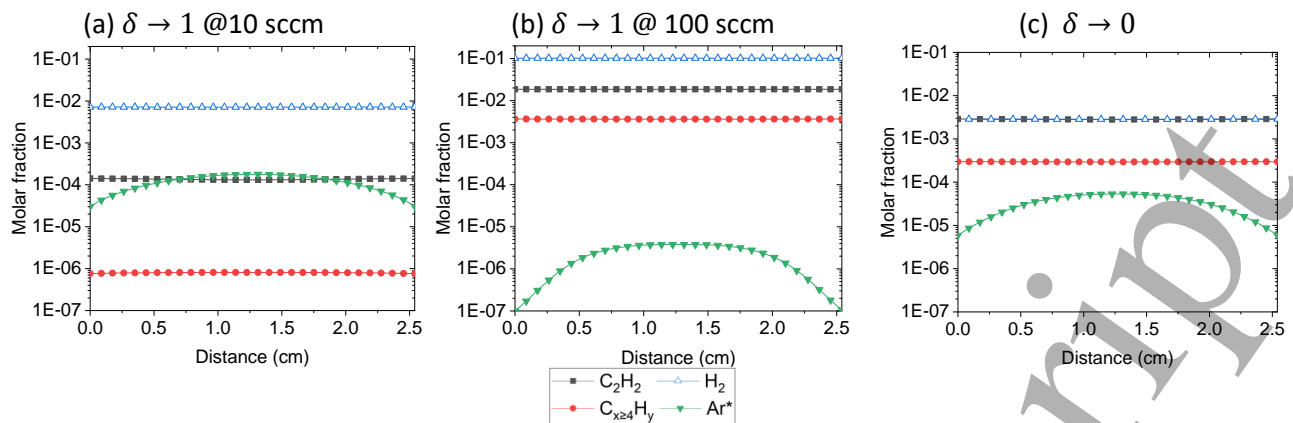


Figure 11 : molar fraction of the neutral species along the discharge different for lateral alimentation conditions

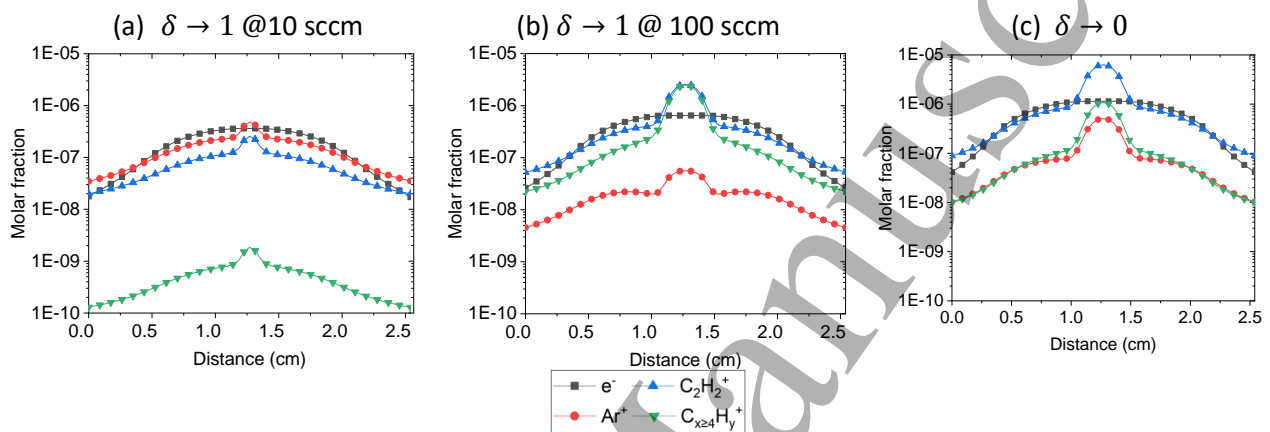


Figure 16 : molar fraction of the positives ion species along the discharge different for lateral alimentation conditions

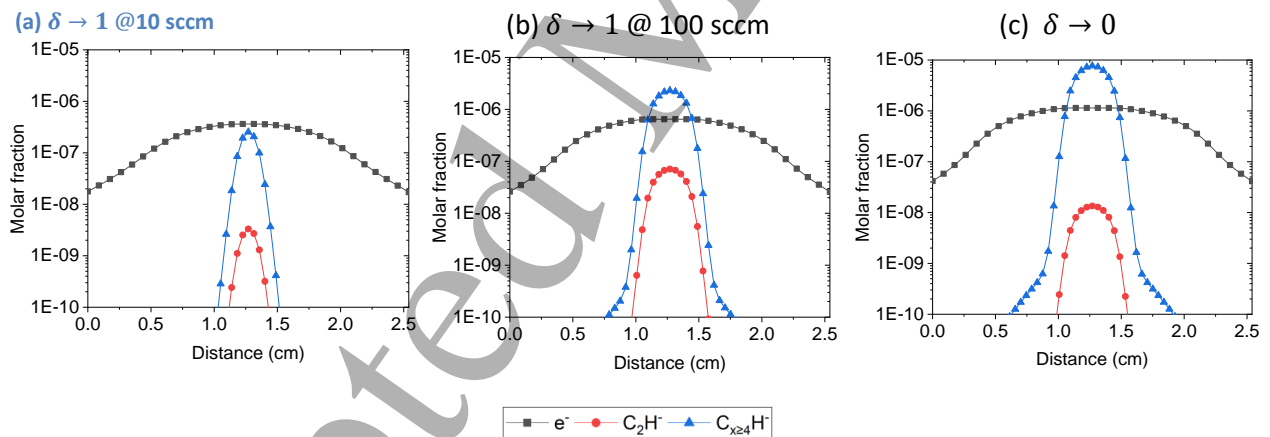


Figure 17: molar fraction of the negative ion species along the discharge different for lateral alimentation conditions

IV. Conclusion

The modeling-based investigation of Ar/ C_2H_2 CCRF discharges presented in this work enables shedding light on the interplay between the discharge dynamic, the plasma kinetics and gas-flow effect in acetylene-argon plasmas. We focused on the molecular growth and nucleation stage and did not take into account solid particle formation and dusty plasma effect in this first study. The model is able to reproduce, at least qualitatively, the trends that have been observed in different experiments with respect to electron density, electron temperature, acetylene conversion yield, argon metastable

density and large HC molecule concentrations. The results obtained explicitly confirm the key-role of argon metastables for all the discharge conditions and flowrate configurations investigated in this work. Whether the plasma is dominated by HC or argon ionization, argon metastables strongly contribute to the ionization and primary dissociation kinetics. This study clearly shows the major impact of the flowrate on the discharge behavior. As a matter of fact, depending on this process parameter, argon-acetylene discharges may (i) be dominated by either hydrocarbon or argon ionization kinetics, (ii) exhibit or not a strong electronegative character, (iii) show different mode of molecular growth. Basically a short residence time (large flowrate) or a large dilution conditions result in a significant concentration of acetylene in the plasma. The discharge is dominated by HC ionization and attachment kinetics that result in a narrow strongly electronegative plasma region at the mid gap and a significant molecular growth through neutral and ions. For large residence-time values, although the acetylene is strongly depleted in the plasma and the discharge is dominated by argon-ion, the contribution of acetylene to the overall ionization kinetics remains significant. The depletion of acetylene results however in the decrease of positive and neutral HC densities while negative ion concentrations remain significant. These would impact the molecular growth kinetics. The simulations performed show that showerhead and remote inlet feed gas configurations yielded similar results for HC species, although the discharge dynamics and hydrogen balance show significant differences between the two configurations at large flowrates. The main differences are a much larger H_2 concentrations and slightly lower electron and Ar^* densities in remote configuration. In fact, more than the flow configuration, an accurate description of the gas flow effect and the boundary conditions remains essential in order to achieve a satisfactory mass balance without any normalization/correction procedure that would introduce a large error on the plasma composition. From the methodological point of view, the simulation carried out in this work clearly emphasized the large stiffness that characterizes argon-acetylene plasmas and results in major difficulties in achieving the (quasi-)permanent regime. From this point of view the solution procedure developed in this study turned out to be fairly effective in treating the stiffness for all the discharge conditions considered in this work. This opens up many perspectives as far as more detailed investigation of molecular growth and plasma-surface interaction over a wide range of discharge conditions is concerned. It also gives the possibility to thoroughly investigate other much longer time-scale effects such as those encountered upon particle formation.

Acknowledgements

This work was partly supported by the French National Research Agency (ANR) through the MONA project (ANR-18-CE30-0016). One of us (KH) is grateful to Institut Universitaire de France for its support.

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